



# Characterization and Fabrication Techniques for Nanoscience and Nanotechnology Research

## Electron Microscopy at Columbia Nano Initiative

The Webinar will  
Begin at 1 PM  
eastern time

**Dr. Nava Ariel-Sternberg**  
Director, Columbia Nano Initiative  
Labs

**Dr. Amir Zangiabadi**  
Director, Electron Microscopy Labs

# This Webinar Is Hosted By



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[atecentral.net/webinars](http://atecentral.net/webinars)



**Dr. Nava Ariel-  
Sternberg**  
Director,  
Columbia Nano  
Initiative Labs



**Dr. Amir  
Zangiabadi**  
Director,  
Electron  
Microscopy Labs



**Robert Ehrmann**  
Managing Director,  
NACK Network

# Webinar Objectives

- ▶ Overview of CNI Shared Labs, research capabilities, and fields of research
- ▶ Overview of Electron Microscopy and sample preparation
- ▶ Examples from recent research projects at CNI using Electron Microscopy



The Fu Foundation  
School of  
Engineering and  
Applied Science

**Columbia Nano  
Initiative**  
Founded in 2014

The Faculty of Arts  
and Sciences

Columbia Nano Initiative  
Administrative Office

Columbia Nano Initiative  
Shared Labs

Supply research services to approximately 100 research groups on campus, external academic institutes and some industrial companies



# Research at CNI

Silicon Photonics

2D Materials and  
Devices

Bioelectronics



Photonics Design  
and Architecture

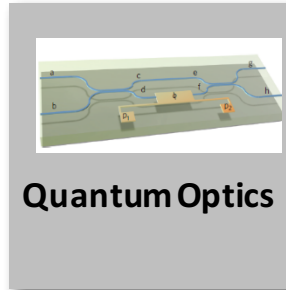
Non conventional  
and flexible  
electronics

Superatoms

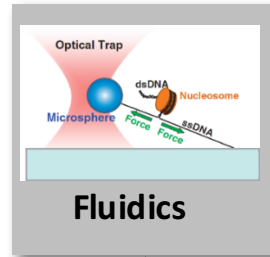
# NOVEL RESEARCH AREAS ENABLED BY SILICON PHOTONICS



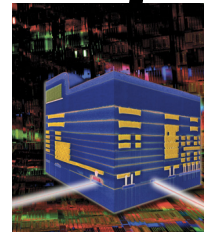
Prof. Michal Lipson



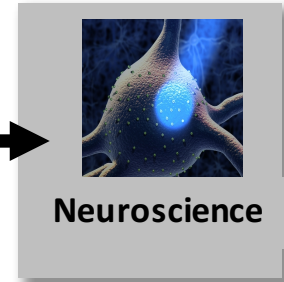
Quantum Optics



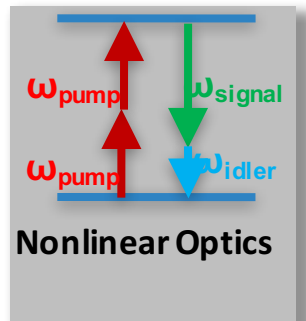
Fluidics



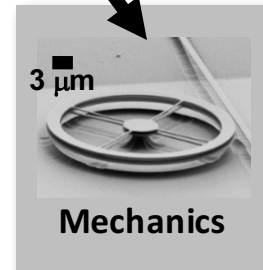
Silicon Photonics



Neuroscience



Nonlinear Optics



Mechanics

<http://lipson.ee.columbia.edu/>

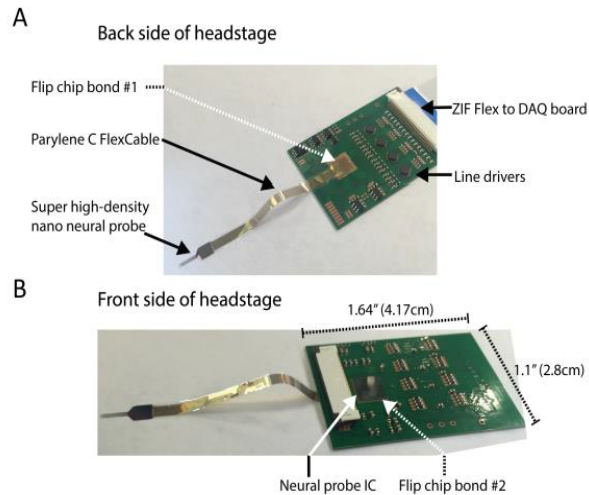


# Bioelectronics for Neuroscience applications: 1024-channel prototype

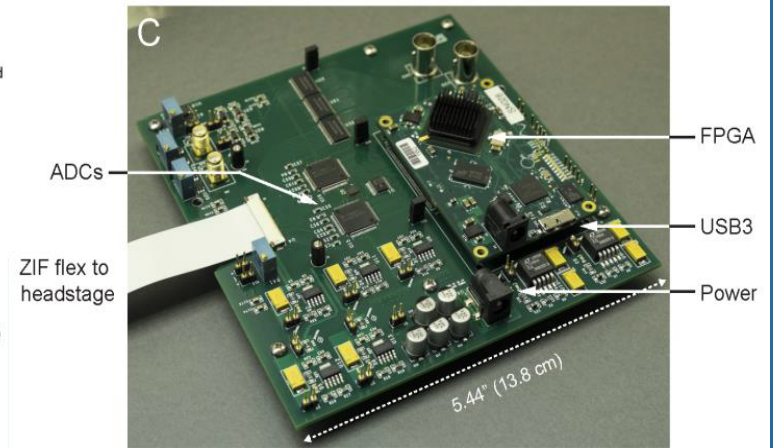
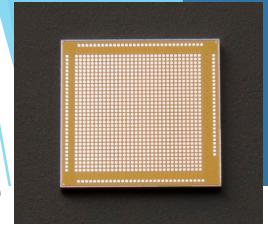


Prof. Kenneth Shepard

1,024 channels per layer. 10 layers.



*In vivo*  
1k-channel  
NeuroProbe



<https://bioeeweb.ee.columbia.edu/wordpress/research/>

Kenneth Shepard, Bioelectronic Systems Laboratory, Columbia University, New York, NY



# CNI Shared Facilities

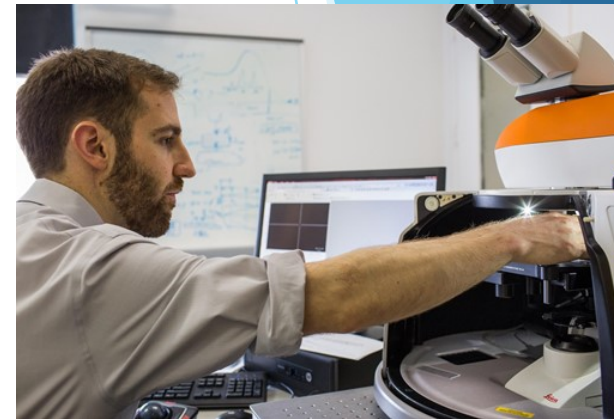
Electron Microscopy



Clean Room



Materials Characterization



Over 400 users from approximately 100 research groups.  
External users are welcome!

# Meet the staff - CNI Shared Facilities



**Dr. Nava Ariel-Sternberg**

**James Vichiconti**

**Dr. Dan Paley**

**Dr. Amir Zangiabadi**

**Nirit Porecki-Shamay**

**Dr. Jaeun (Jen) Yu**

**Melody Gonzalez**

**Director of Shared Facilities**

**Director of Clean Room**

**Director of SMCL**

**Director of EM lab**

**Senior Clean room Engineer**

**Clean room Engineer**

**Research Operation Assistant**

# CNI Clean Room

- ▶ An environmentally controlled lab - tight limits for temperature and humidity, air exchange
- ▶ Particle filtering, class 1000 to 10,000
- ▶ Clean room apparel

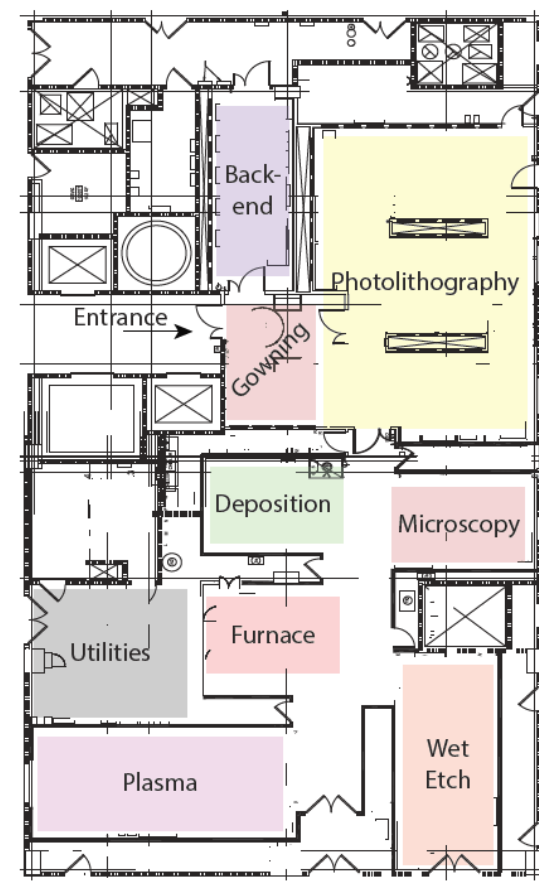
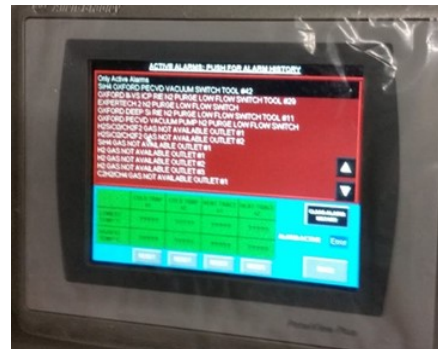
<b>Airborne Particulate Cleanliness Classes (by cubic meter):</b>						
CLASS	Number of Particles per Cubic Meter by Micrometer Size					
	0,1 micron	0,2 micron	0,3 micron	0,5 micron	1 micron	5 microns
ISO1	10	2				
ISO2	100	24	10	4		
ISO3	1,000	237	102	35	8	
ISO4	10,000	2,370	1,020	352	83	
ISO5	100,000	23,700	10,200	3,520	832	29
ISO6	1,000,000	237,000	102,000	35,200	8,320	293
ISO7				352,000	83,200	2,930
ISO8				3,520,000	832,000	29,300
ISO9				35,200,000	8,320,000	293,000



\*Terra Universal Inc.

# Clean Room Utilities and Supporting system

- ▶ Non Contact Cooling Water system to cool equipment
- ▶ DI water supply for processing
- ▶ N2 and compressed dry supply
- ▶ AHUs, dehumidifier and Clean Steam Generator for tight temperature and humidity control
- ▶ Exhaust for chemicals fumes and air exchanges
- ▶ Lab monitoring system
- ▶ Safety systems - Toxic Gas monitoring System (TGMS)





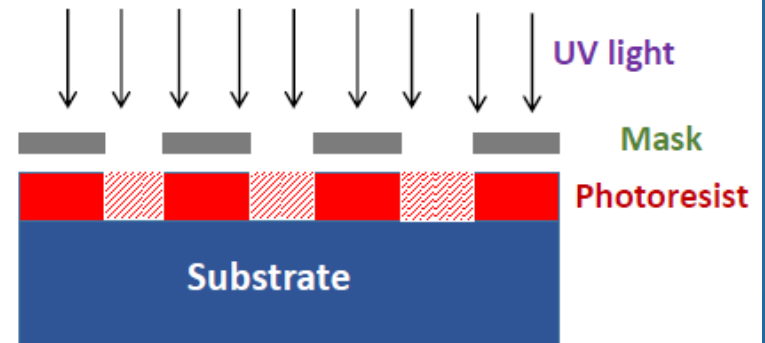
# Patterning: Photolithography and Etch



- Suss Mask aligner for UV exposure down to 248nm (sub-micron resolution)



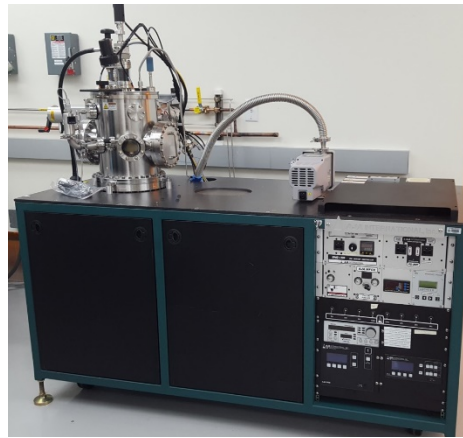
- Oxford Reactive Ion Etching



# Deposition and thin film growth



Expertech LPCVD furnace



AJA magnetron sputtering



Angstrom e-beam evaporation

## Back End: Connecting the device to the outside world



Westbond Wirebonders



Disco DAD 3220 Dicing saw



CMP: Poli-400L

# Materials Characterization Lab

Surface Analysis and surface area

Crystallographic structure and orientation

Particle size, Molecular weight distribution, and Z-potential

Optical and Magnetic Properties

Molecular structure and bonding information

Thermal Properties

2D materials device fabrication and characterization





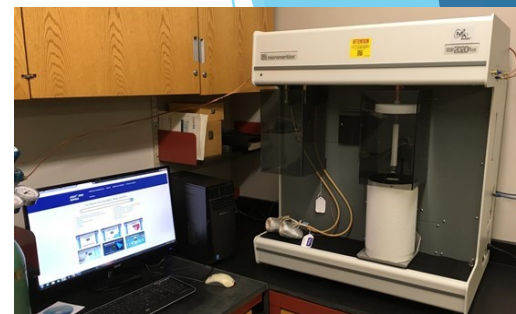
# Surface Analysis and bonding



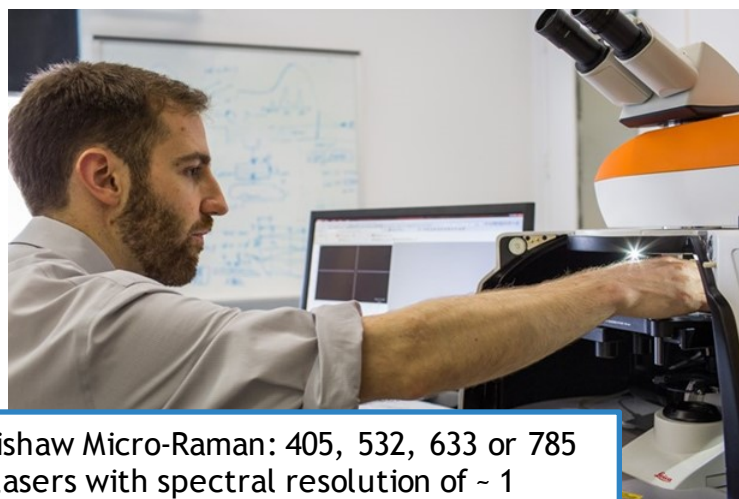
XPS: For surface elements survey and depth profiles



Bruker AFM

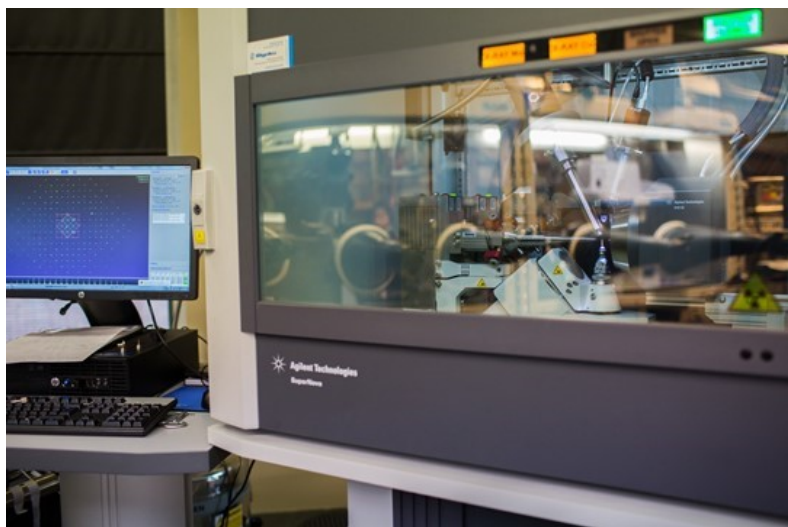


BET analyzer: Surface area by measuring nitrogen adsorption isotherms for porous materials at 77 K.



Renishaw Micro-Raman: 405, 532, 633 or 785 nm lasers with spectral resolution of ~ 1

## Crystallographic structure, phase, orientation Information



Agilent SuperNova SCXRD: Mo/Cu dual micro-focus source of 50W.

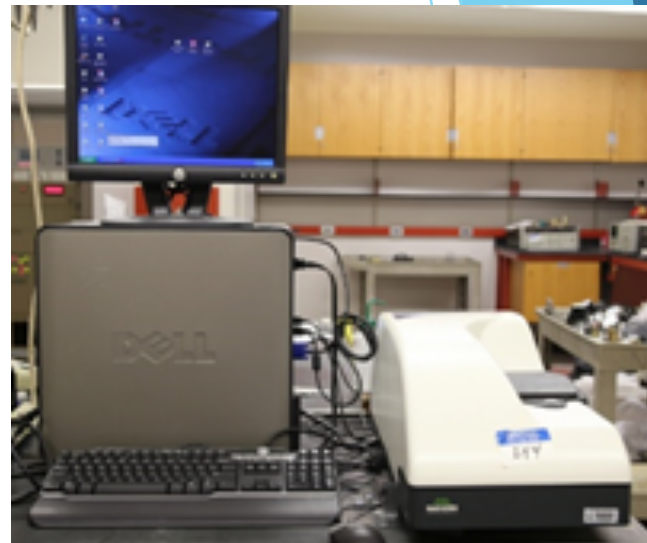


PANalytical PXRD: For powder crystallographic analysis. Temp. measurements in the  $-173$ - $400^{\circ}\text{C}$  range

## Particle size, Molecular size distribution, and Z-Potential

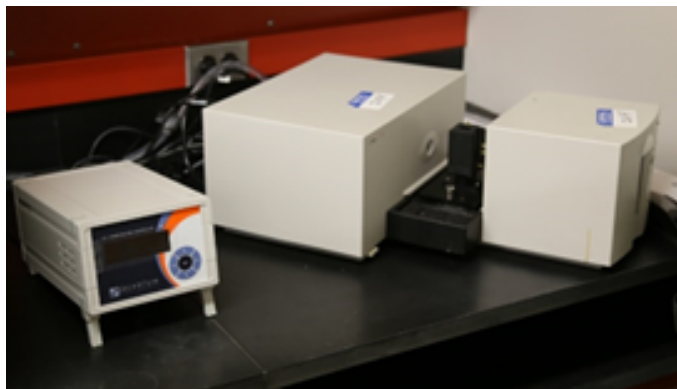


GPC: gel permeation chromatography analysis of polymers at different solvents and temperatures.



Dynamic Light Scattering (DLS) and Z-potential to measure: particle size, molecular weight, and zeta potential for organic and aqueous colloids, nanoparticles, and proteins.

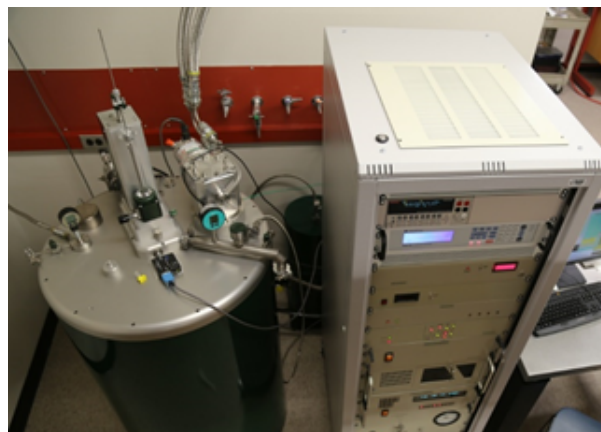
## Optical and Magnetic Characterization



Spectrophotometer: measuring absorbance in the 190-1100 nm range. Temp measurements in the -20-110°C.



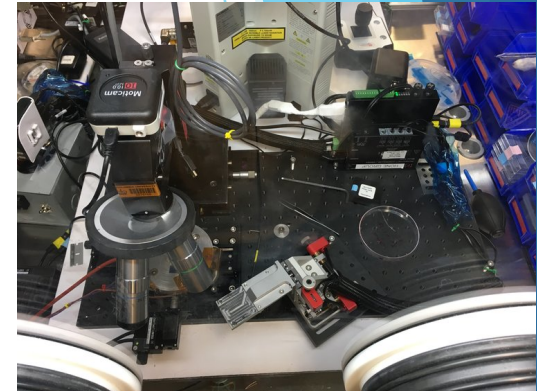
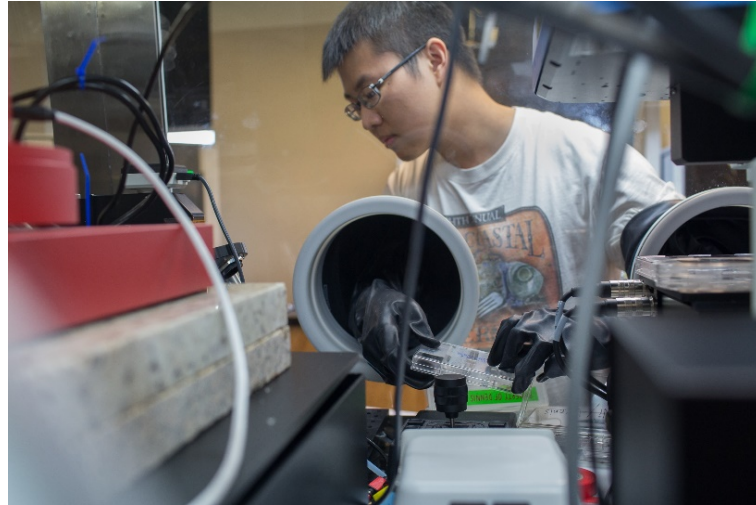
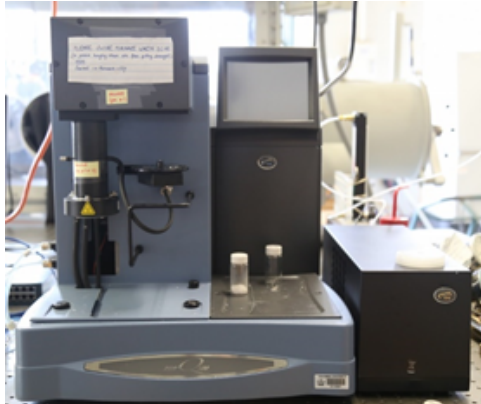
Woollam Ellipsometer: thin film thickness and refractive index measurements



SQUID: DC and AC measurements of magnetic susceptibility. Sample temperature between 1.8 and 300 K.



## Thermal Properties and 2D materials device fabrication and Characterization



TGA: Thermal analysis temperatures between ambient and 1000 °C.

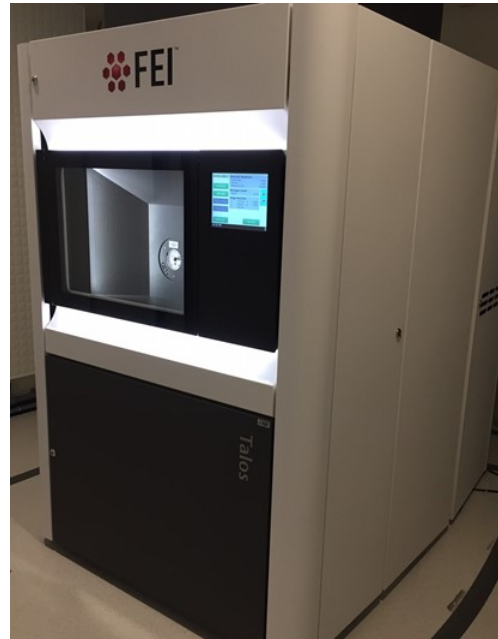
2D Material processing in protective environment: Autofinder (microscope with computer-controlled xyz axes and a remote-controlled micromanipulator, 0.5 $\mu$  precision)

# Electron Microscopy and Imaging



FEI Nova NanoSEM 450:

- FEG with Through lens SED, Everhart Thormley SED, Low Vacuum SED, Through lens BSED detectors.
- NPGS - Nability system for e-beam writing



FEI Talos F200X TEM/STEM:

- Max acc voltage of 200 kV, configured for 80kV as well
- Super X-EDS system; 4 Silicon drift detectors (SDD)
- TEM point resolution (nm) 0.25
- Sample preparation suite



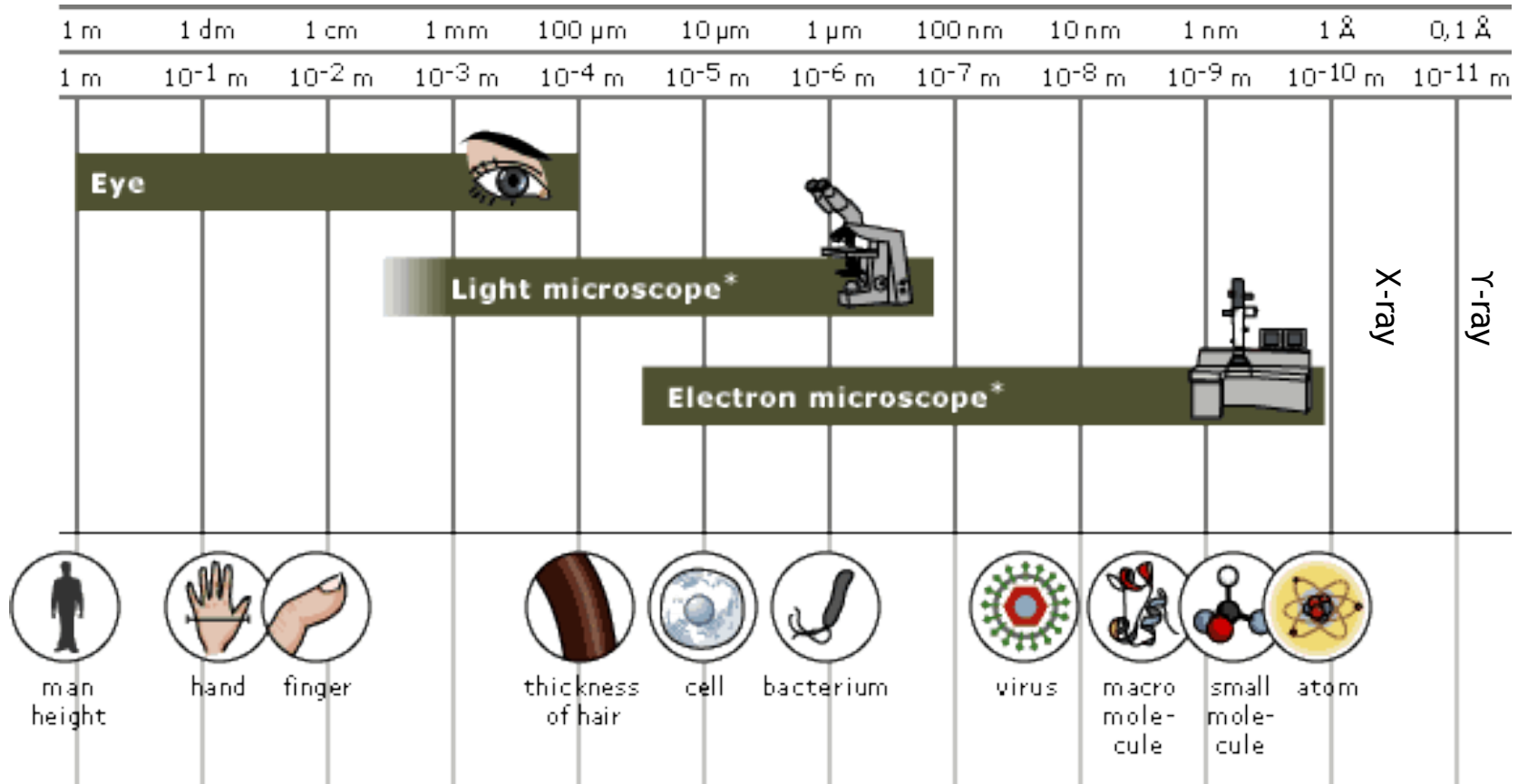
Sigma VP Zeiss SEM:

- FEG with Inlens, SE, BSED and VPSE detectors
- Bruker EDS system

# Types of Microscope

Using electrons to “see” objects to atomic level

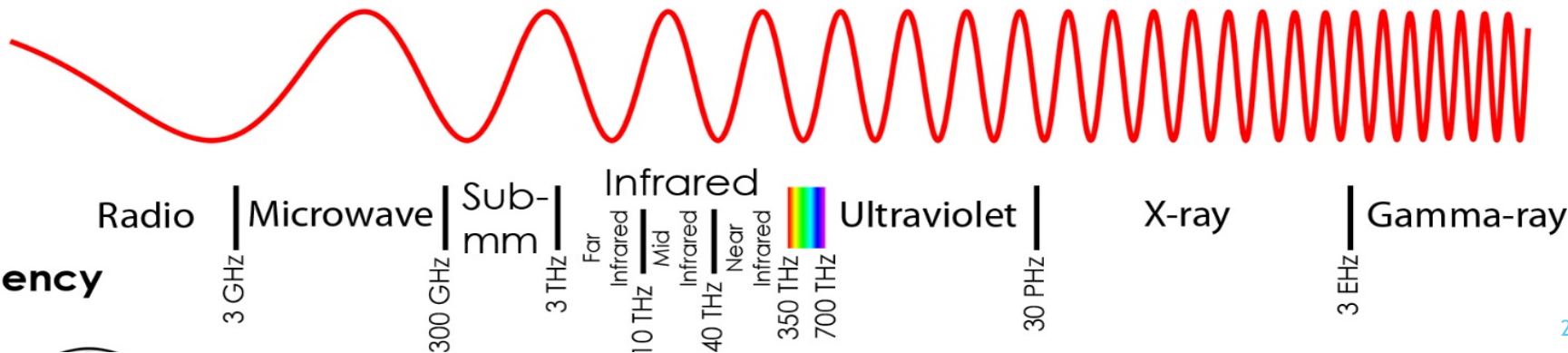
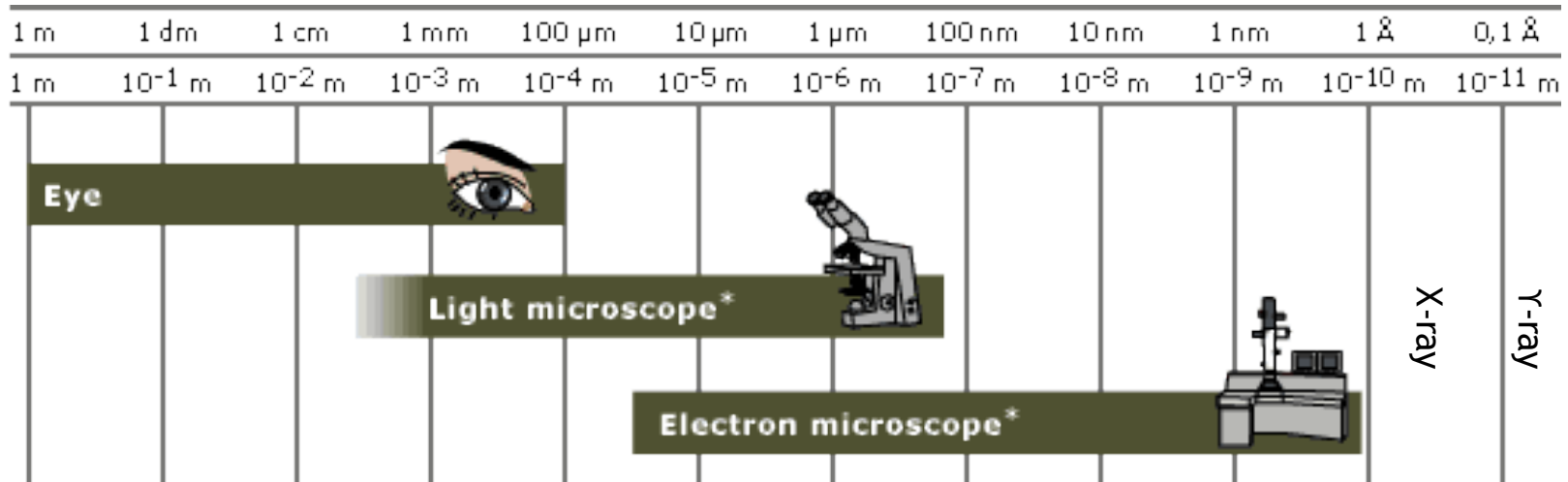
- ❑ Similar to optical microscopy except with electrons rather than photons
- ❑ Used to image samples with a resolution of 10 Å
- ❑ Can image many different structural geometries
- ❑ Mostly limited by radiation damage from the electron beam



# Types of Microscope

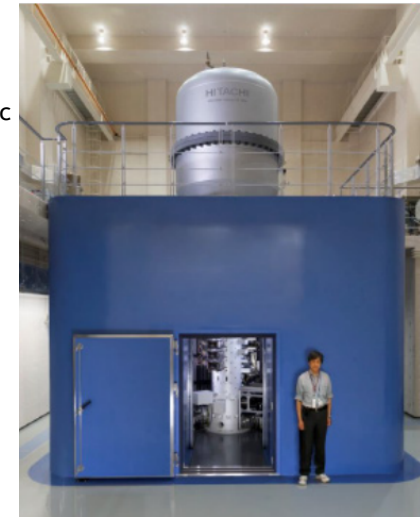
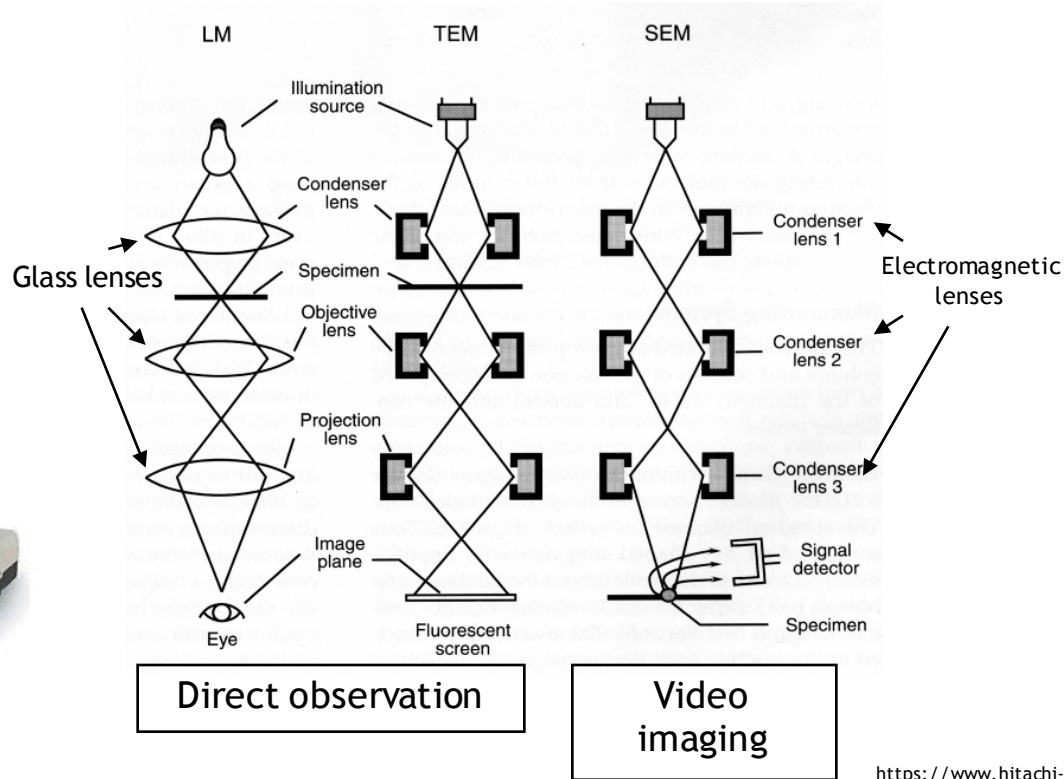
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# Electron Microscope

Same principle, but in very different shapes

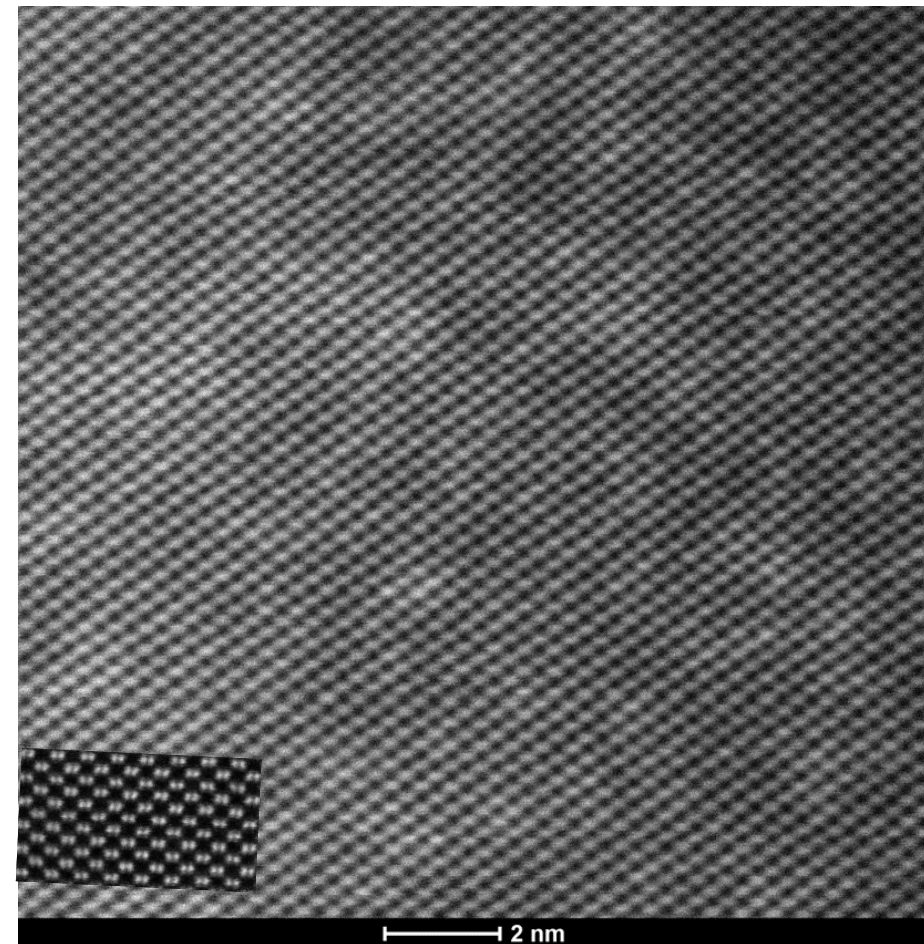


[https://www.hitachi-hightech.com/global/sinews/si\\_report/07046/](https://www.hitachi-hightech.com/global/sinews/si_report/07046/)

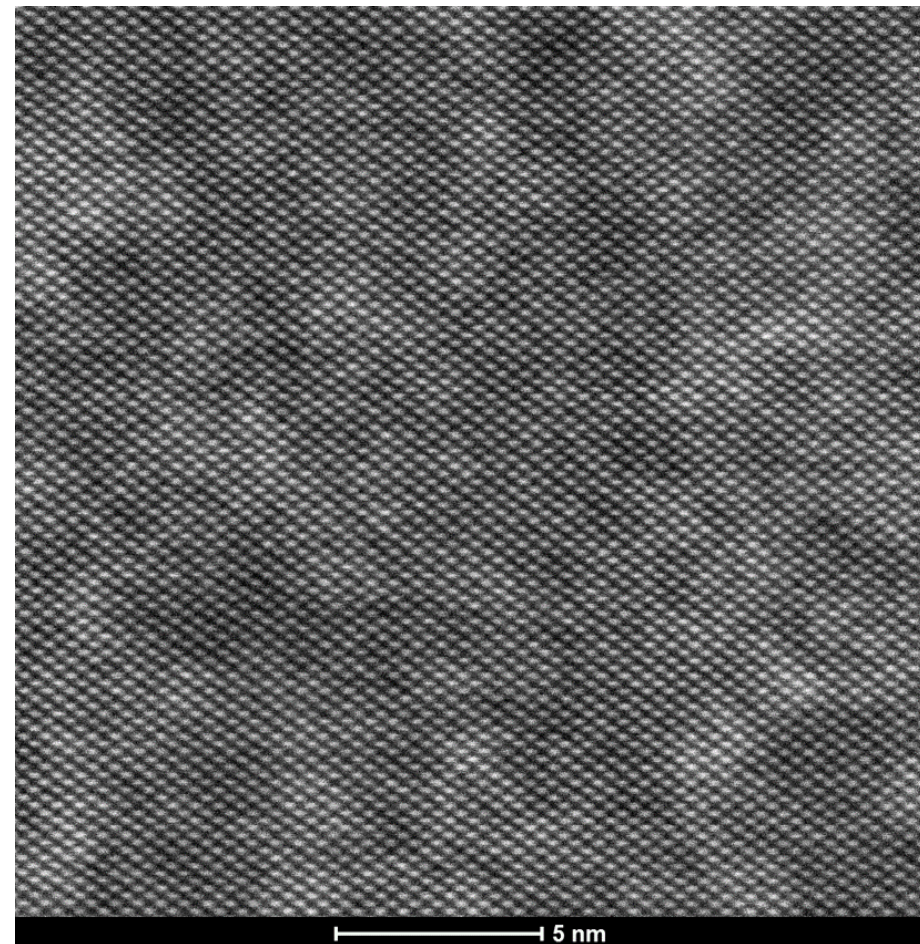


# Testing the Resolution in STEM

May 2017



March 2015 (approved in Czech Republic)



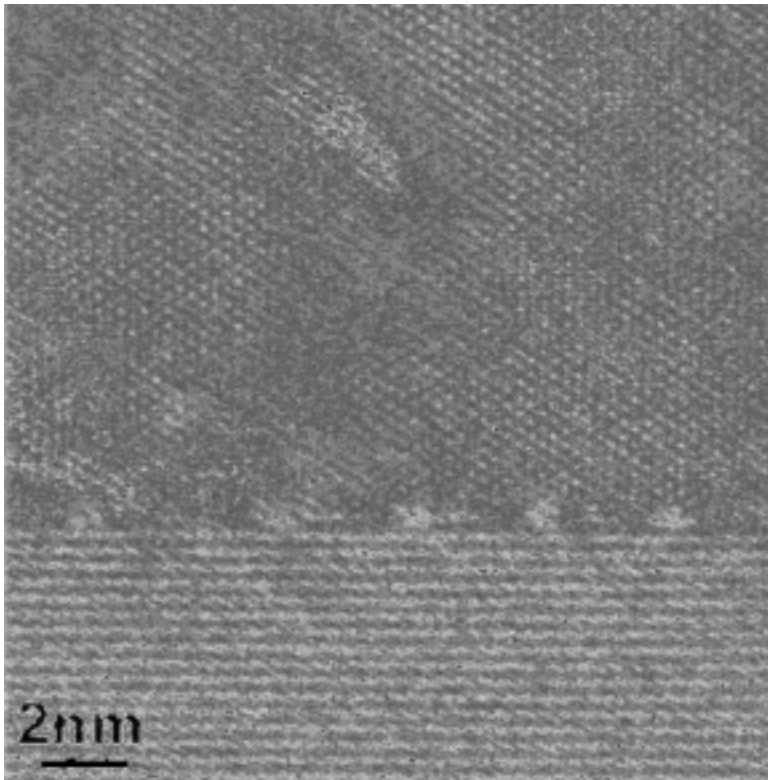


# Specimen Preparation

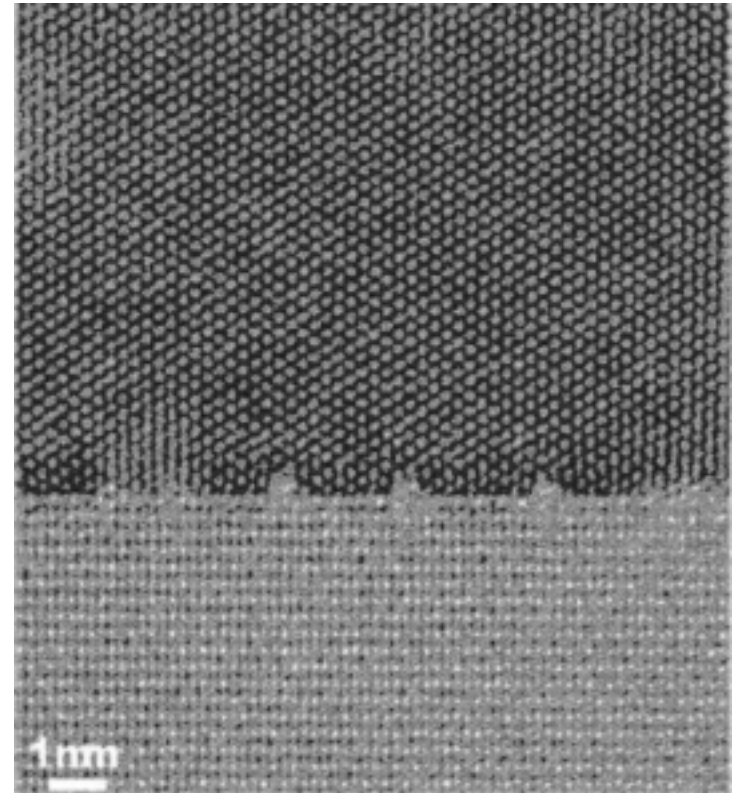
- general techniques for materials sciences

# Why Sample Preparation is so Important?

- Bad sample prep, unclear observation, wrong analysis!



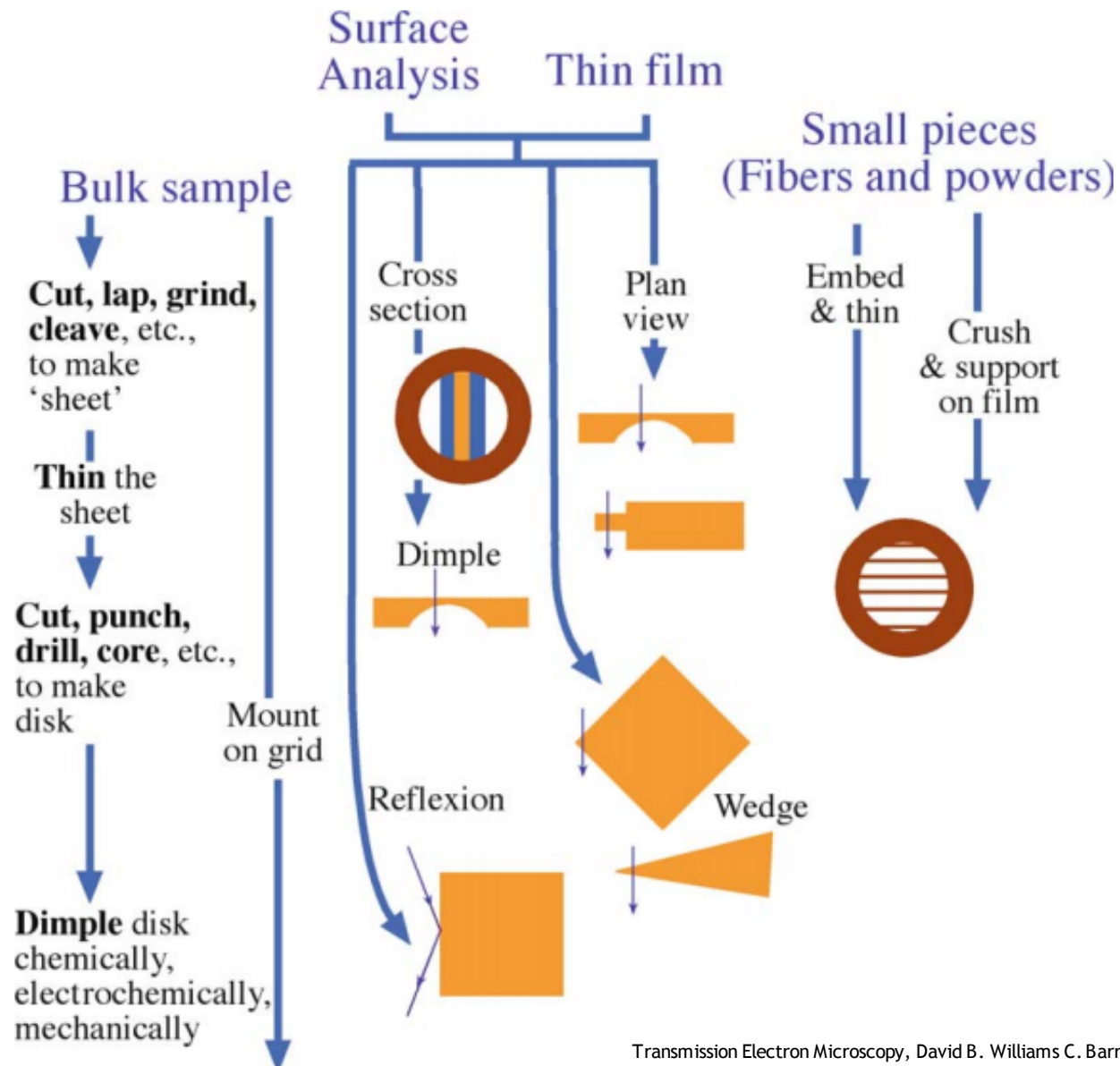
Cross section, Ion Milling (>2kV)



Cross section, Ion Milling (down to 100V)

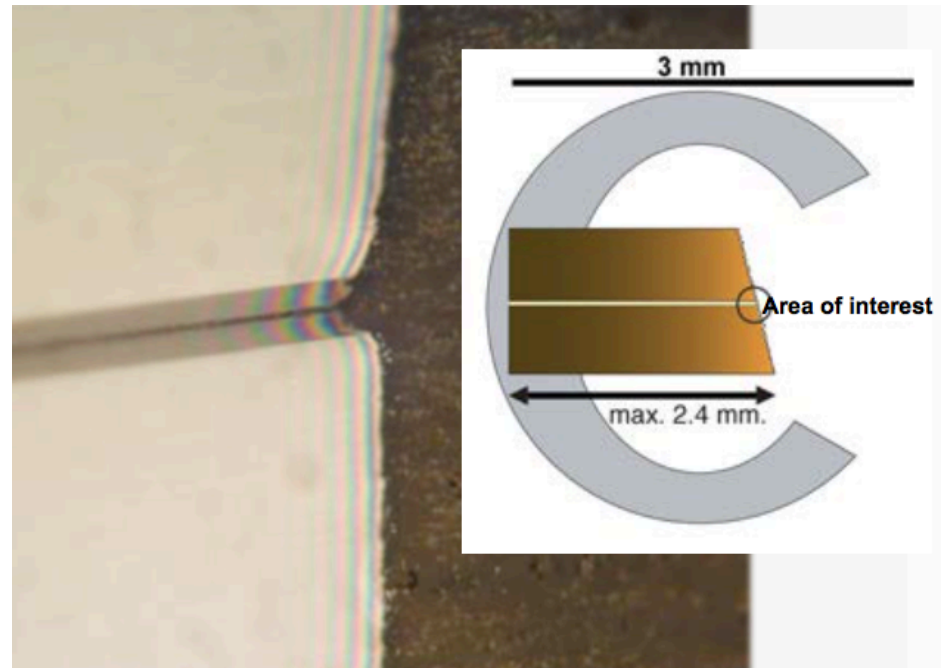
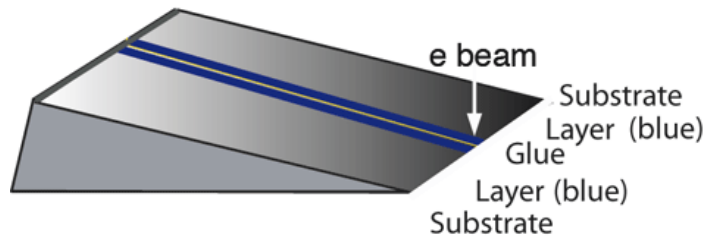


# Sample Preparation Overview



# Mechanical → Tripod Method

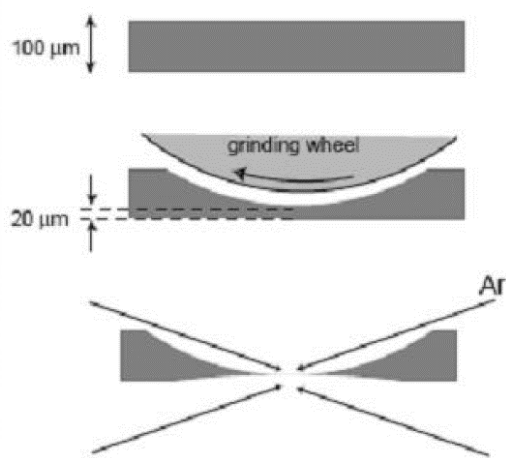
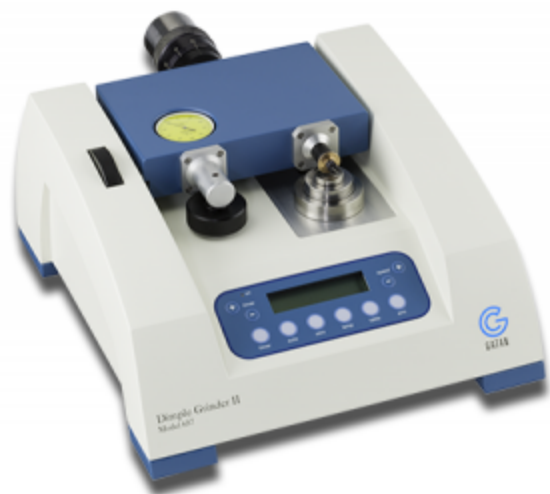
- Mechanical thinning, in a wedge configuration, down to electron transparency or to a thickness that requires very short ion milling time.
- Polishing with diamond-impregnated lapping films; Finish with colloidal silica



TiO<sub>2</sub> / Silicon,  
Optical microscope, reflected light

# Dimple Grinding

Thinning the central part of the sample to less than 20  $\mu\text{m}$  before ion milling.



Mechanical grinding  
+  
Polishing

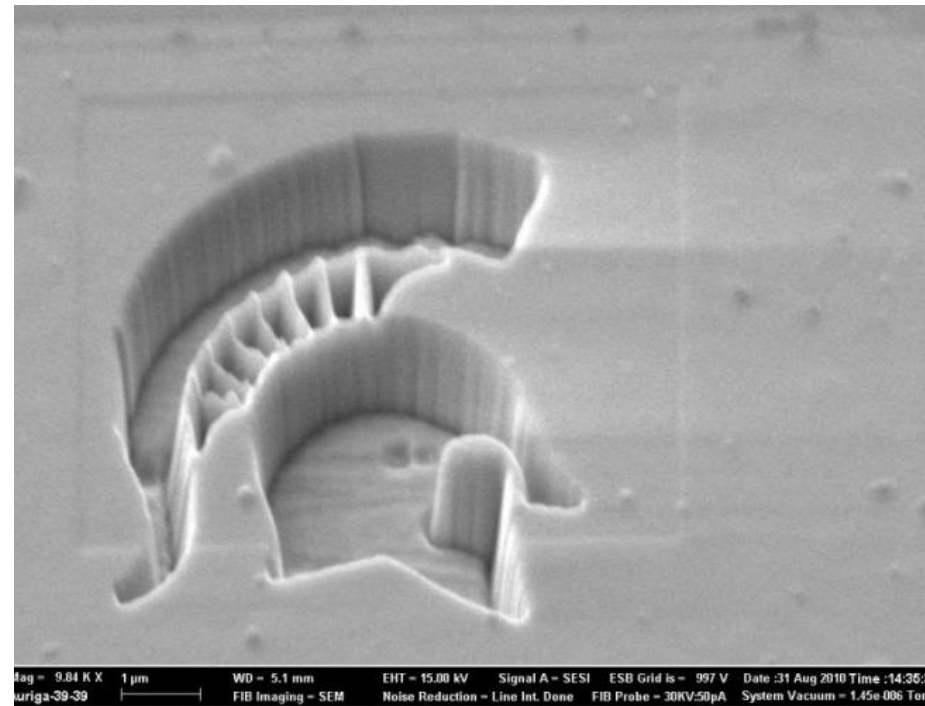
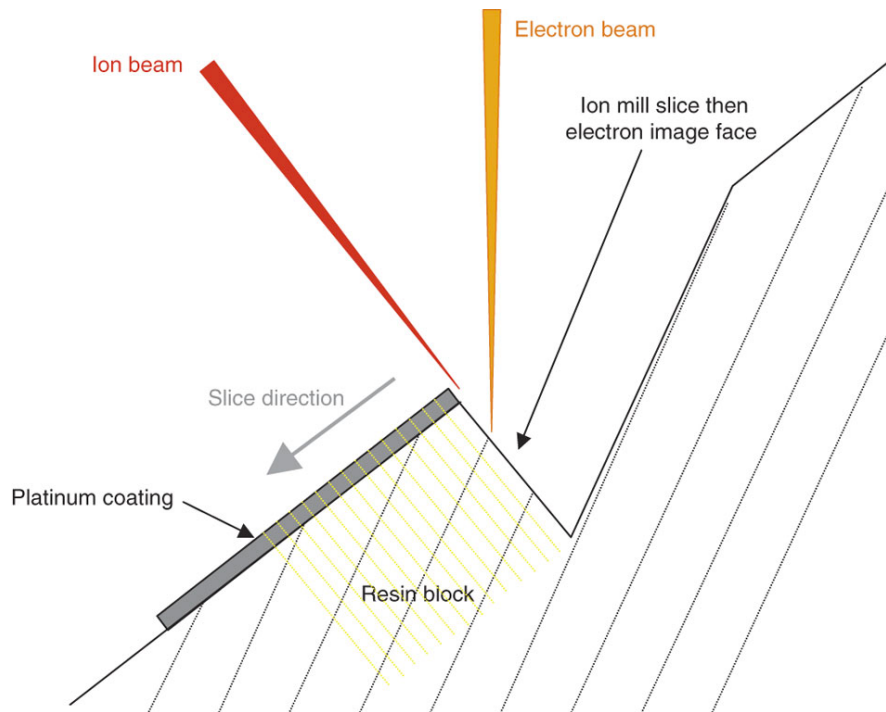
Dimple Grinding

Ion milling



# Focused Ion-Beam (FIB) - Collaboration with CUNY

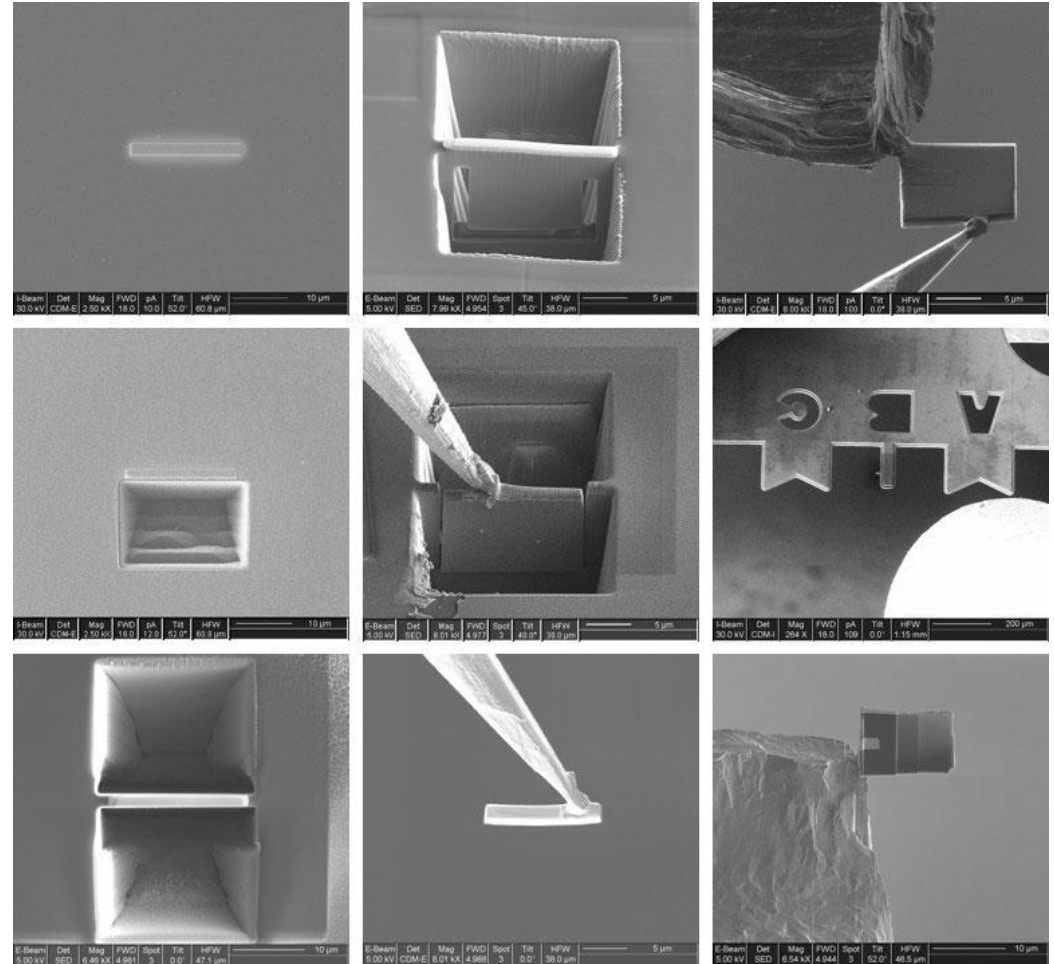
Using precise focused ion beam to select the sample. Then using manipulator to pickup the sample



<http://www.nature.com/nprot/journal/v6/n6/abs/nprot.2011.332.html>

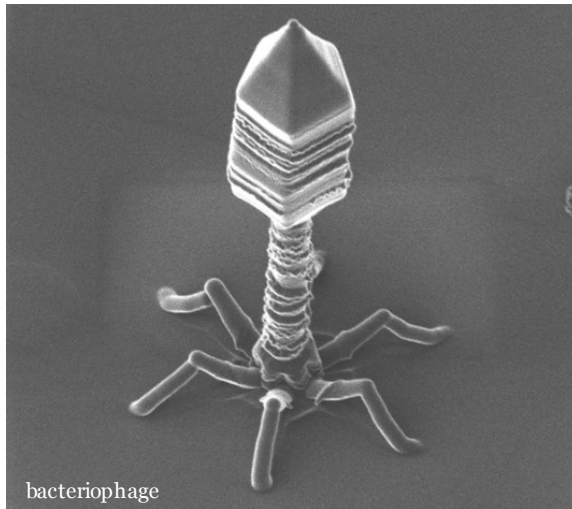
# **Focused Ion Beam (FIB) Sample Preparation**

# Focused Ion-Beam (FIB)

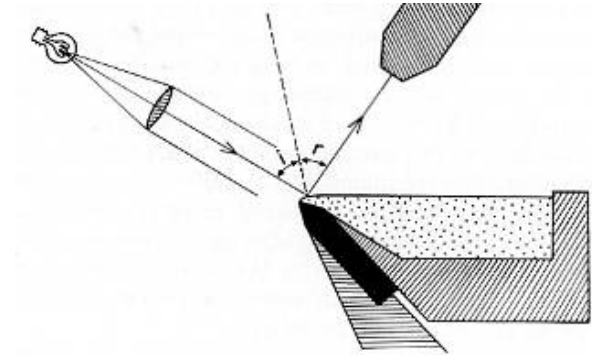
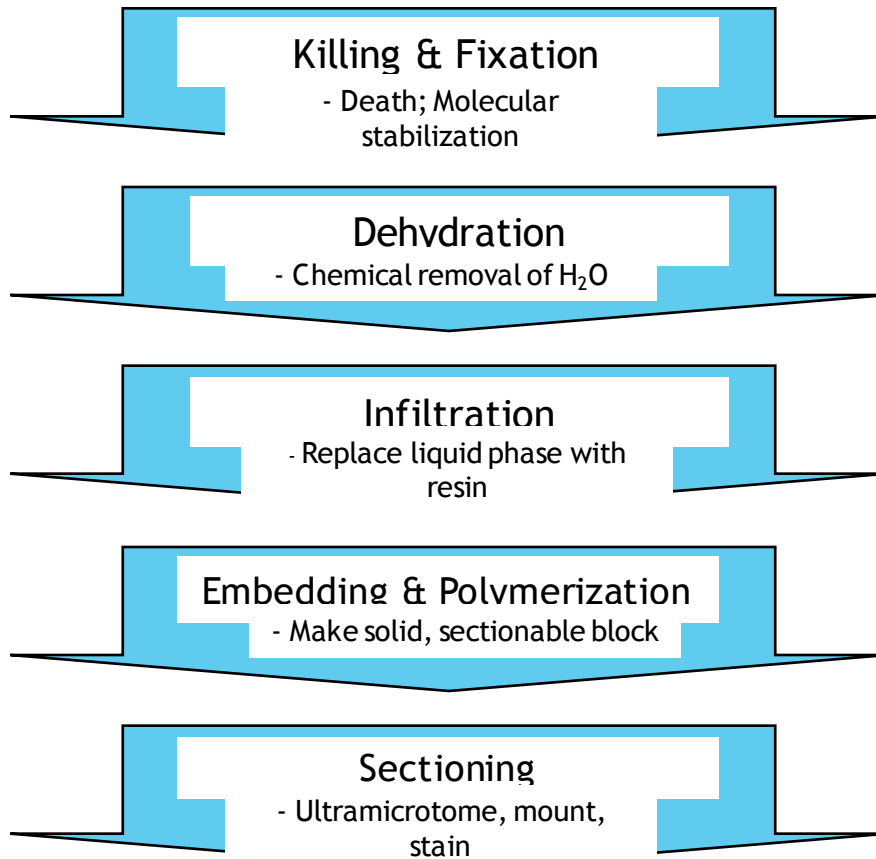




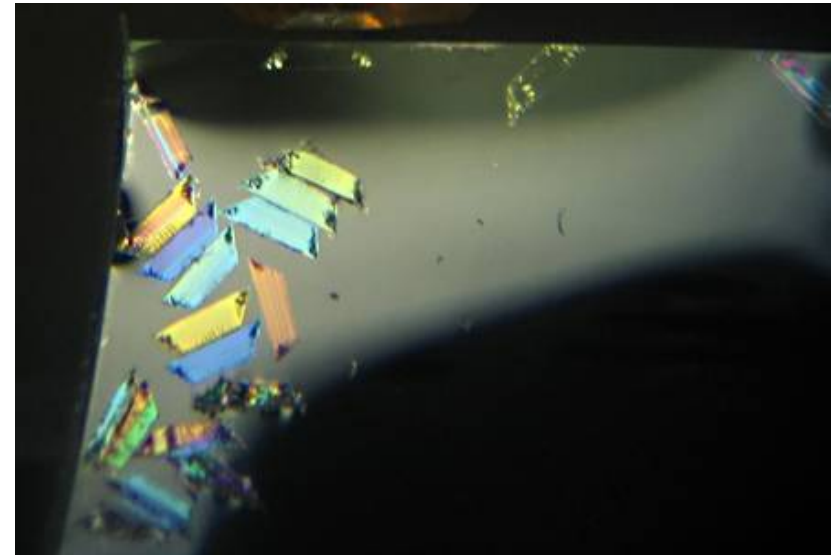
# Biological Specimen Preparation



# Overview of Biological Specimen Preparation - Focusing on Sectioning



Interference reflection angle from Sjöstrand (1967)

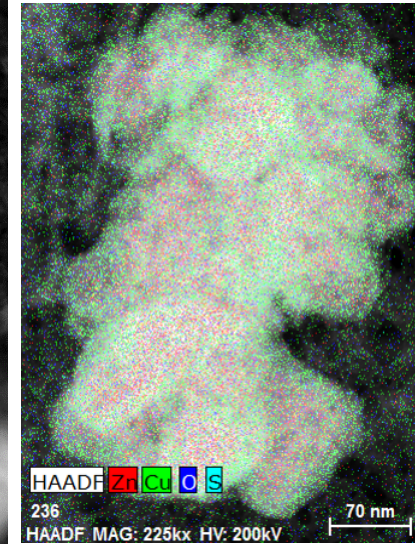
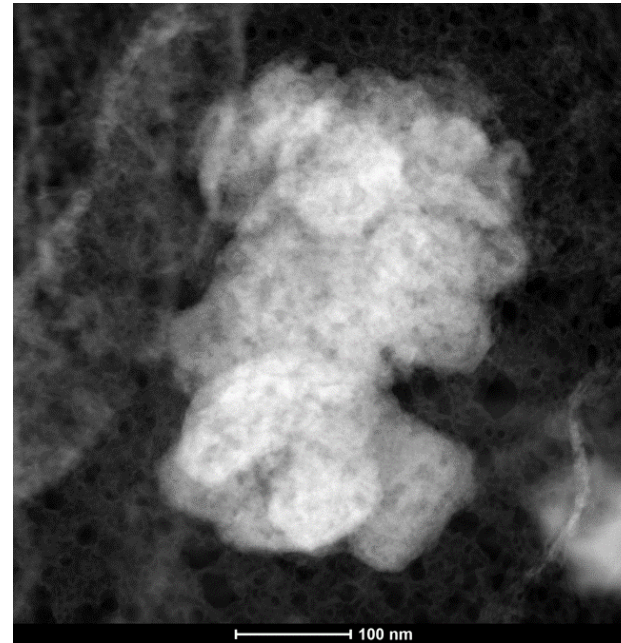
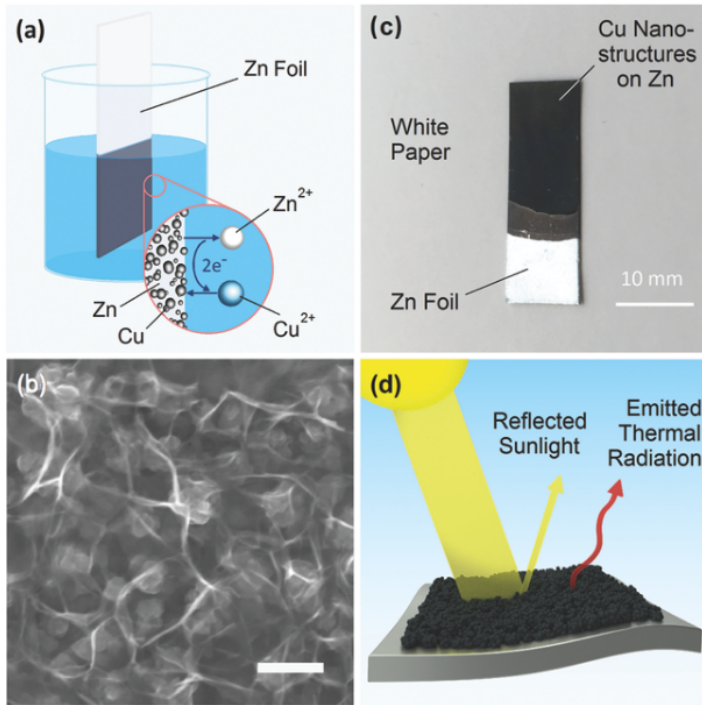




# Examples from Research Studies at Columbia Nano Initiative Columbia University



# Solar-Thermal Energy Absorber



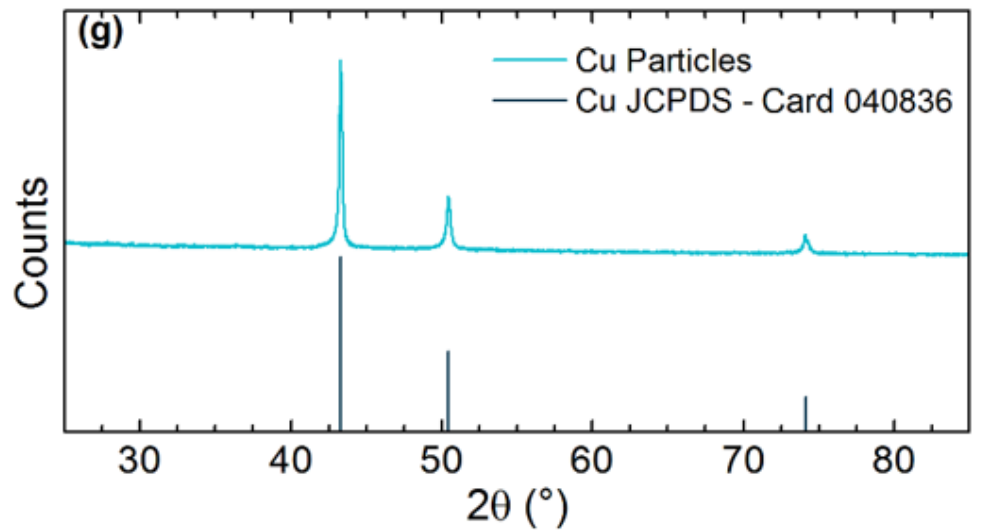
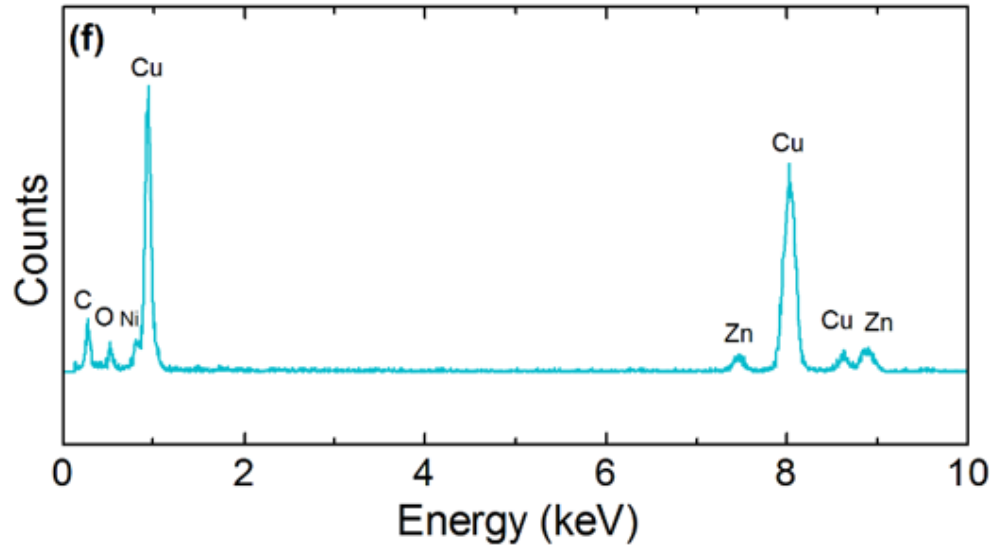
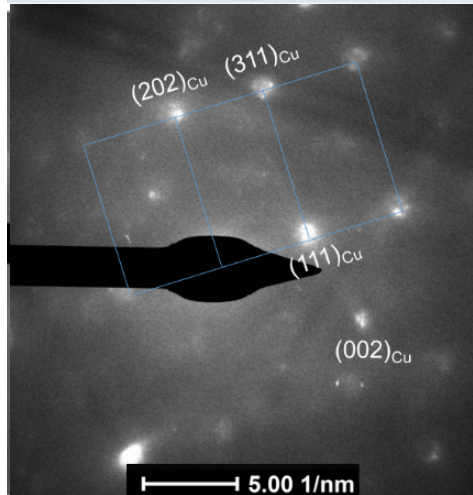
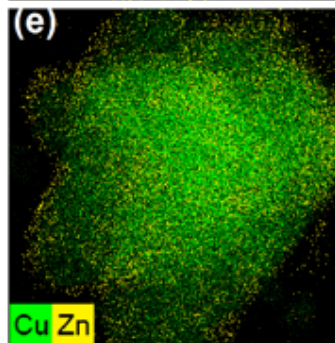
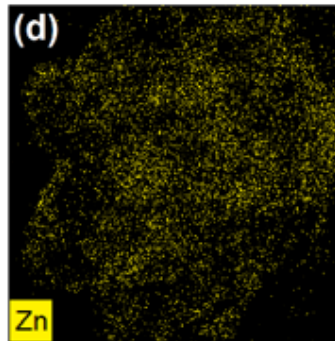
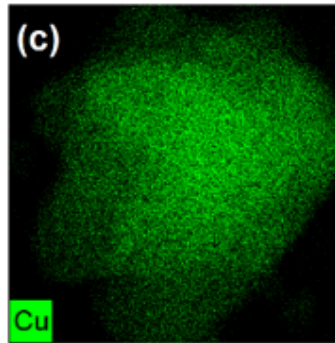
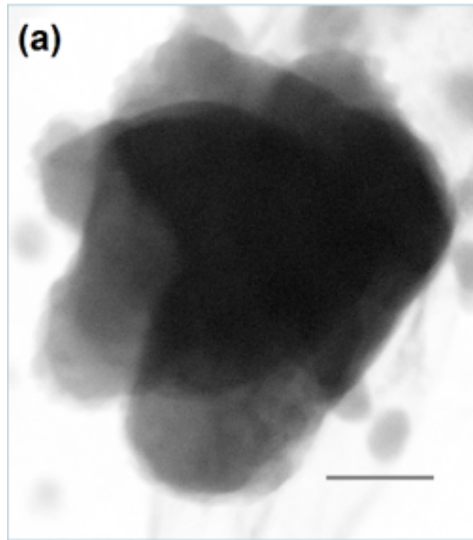
At 200 C, copper tends to diffuse outside of the particles

J. Mandal et al, Adv. Mater. 2017, 29, 1702156

Courtesy of Prof. Y. Yang



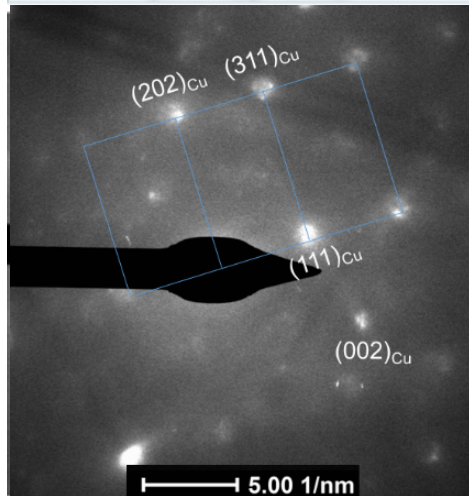
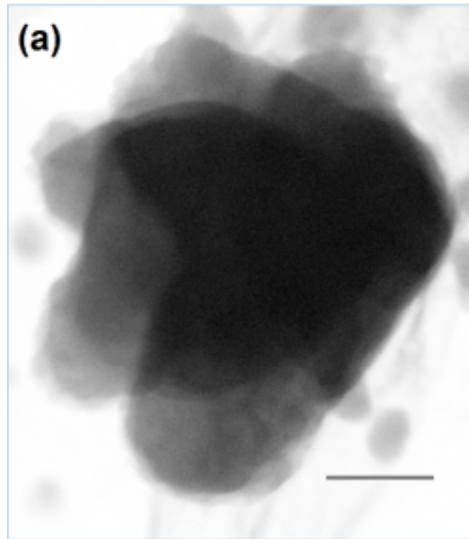
# Solar-Thermal Energy Absorber



J. Mandal et al, Adv. Mater. 2017, 29, 1702156

Courtesy of Prof. Y. Yang

# Solar-Thermal Energy Absorber

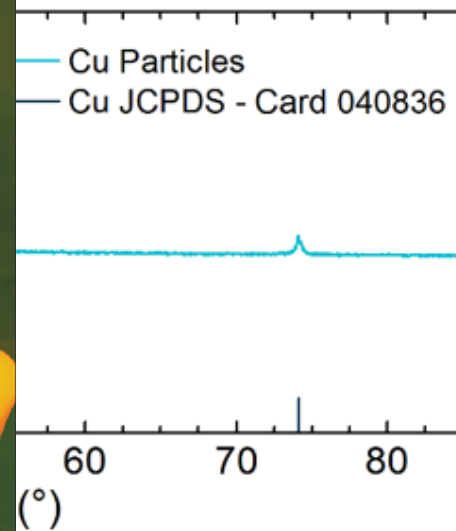
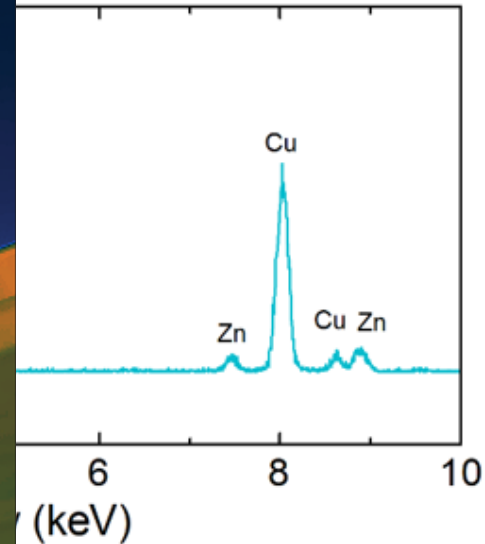


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## ADVANCED MATERIALS

J. Mandal et al, Adv. Mater. 2017, 29, 1702156

WILEY-VCH



# Light Emitting Graphene

Applying voltage between two graphene layers leads to a short emission of light in specific spectrum  
(green, blue,...)



Cr/Au 5nm/300nm

SiO<sub>2</sub> ~285nm

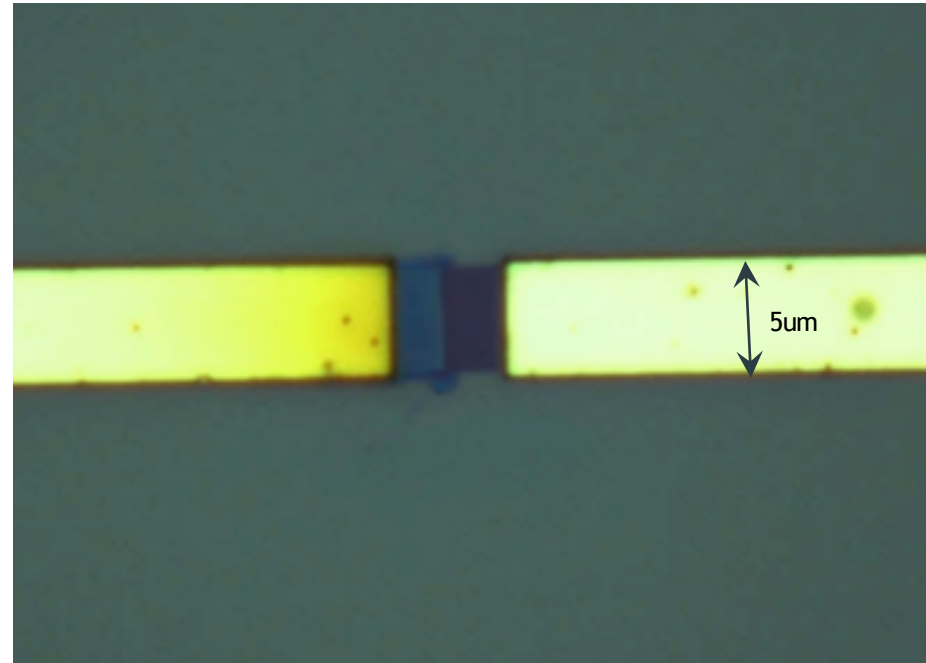
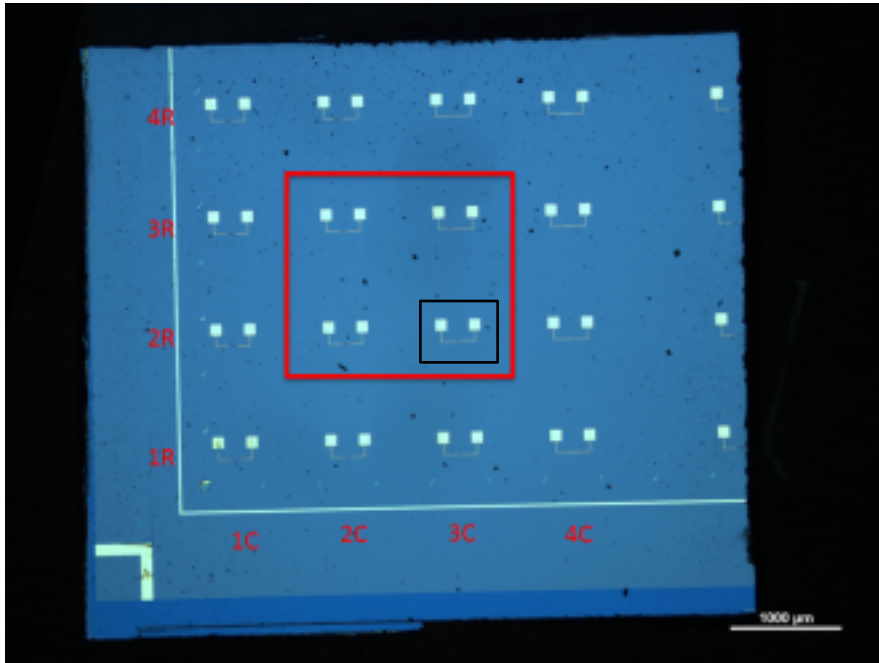
Graphene 5nm (red color)

graphene oxide ~20nm (green color)

Si substrate 500um

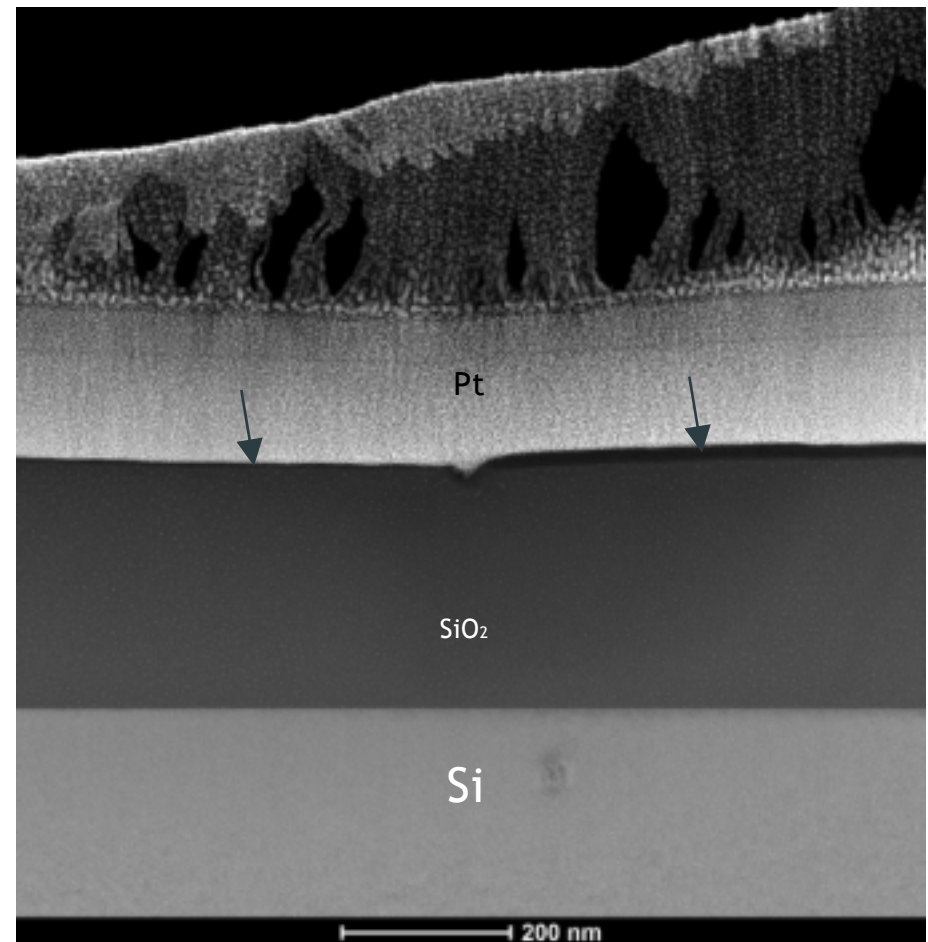
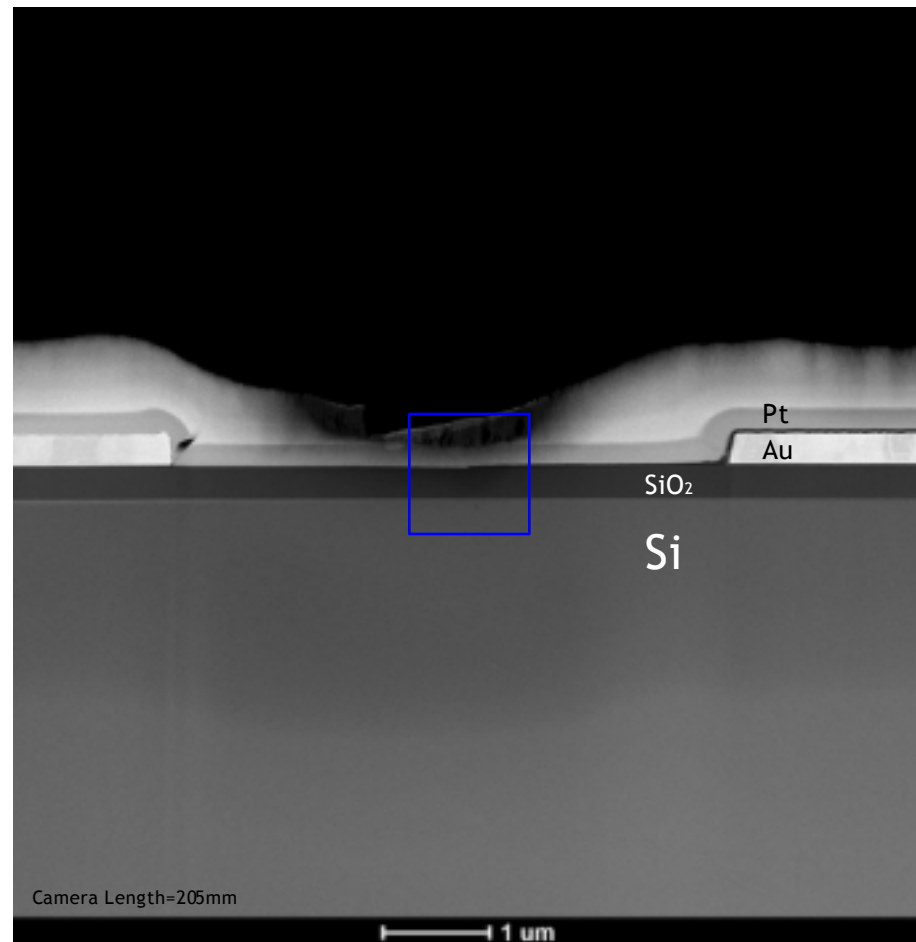
# Light Emitting Graphene

Making cross sectional TEM sample to study the chemistry and structure of the intersection



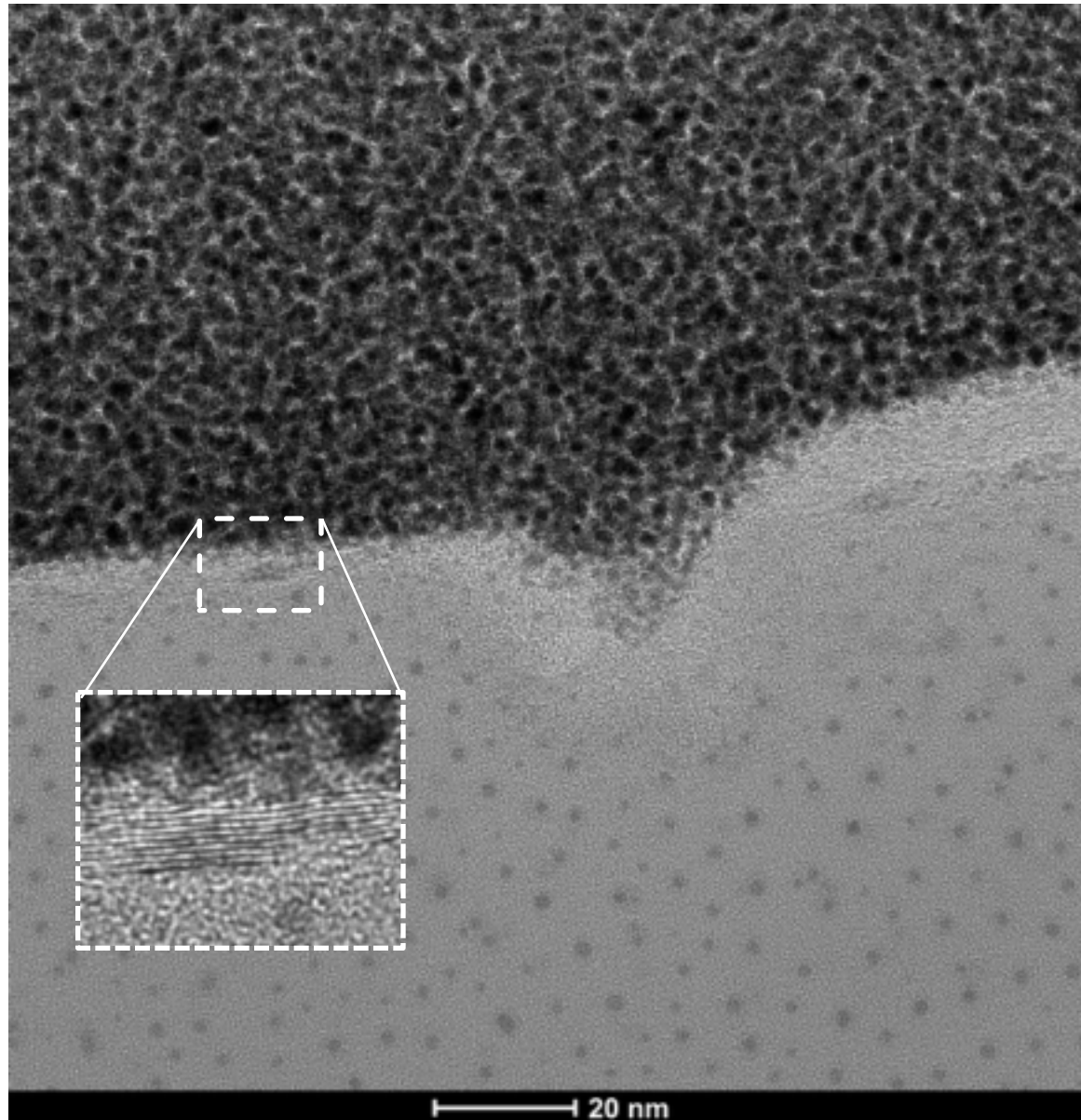


# STEM imaging



# Light Emitting Graphene

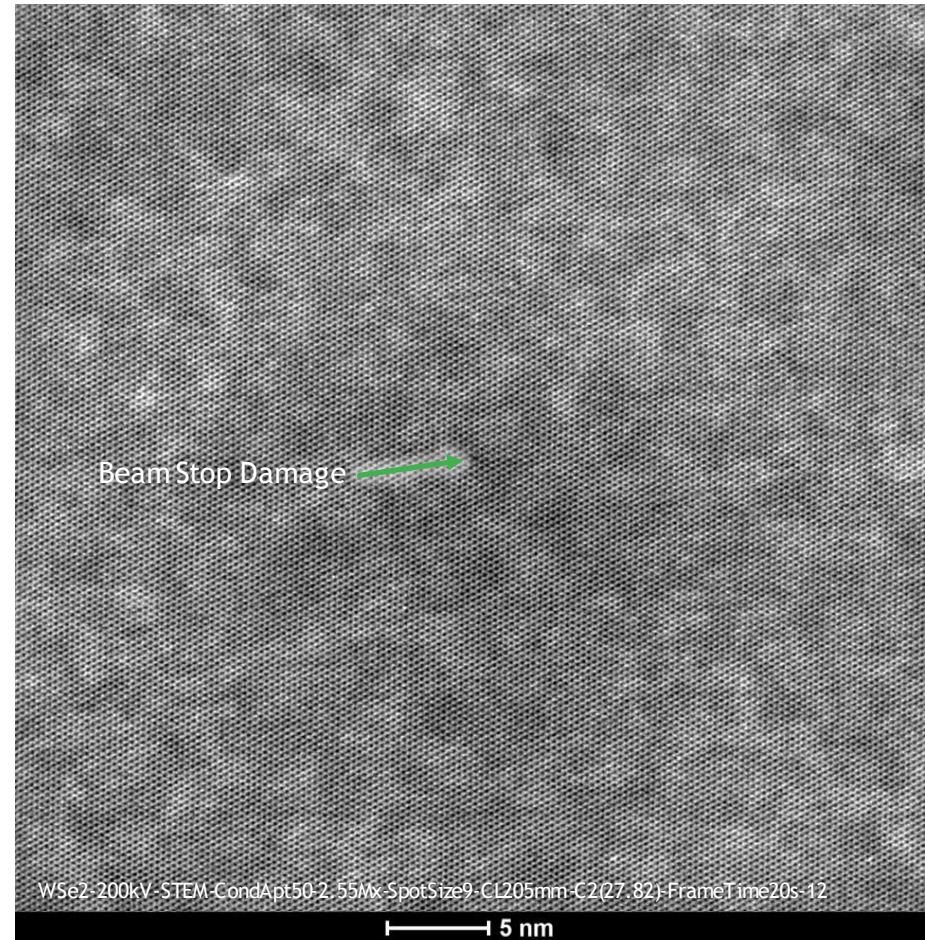
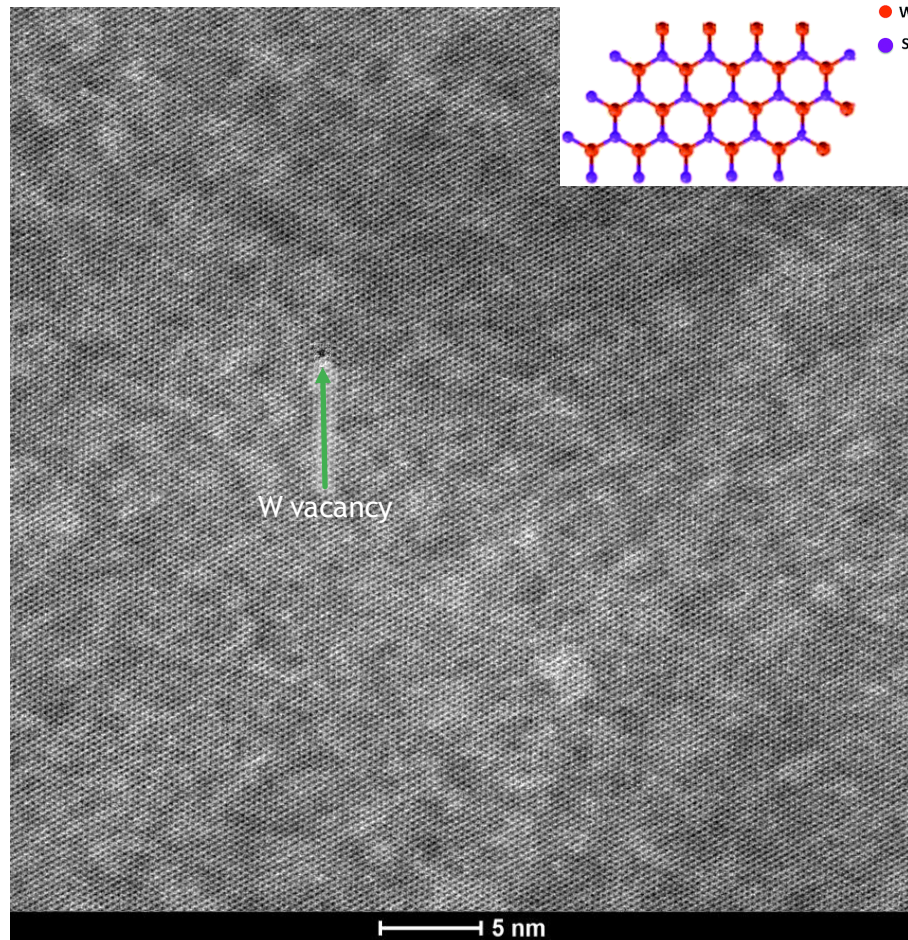
TEM-BF-imaging





# Single Layer WSe<sub>2</sub> - Tungsten vacancy

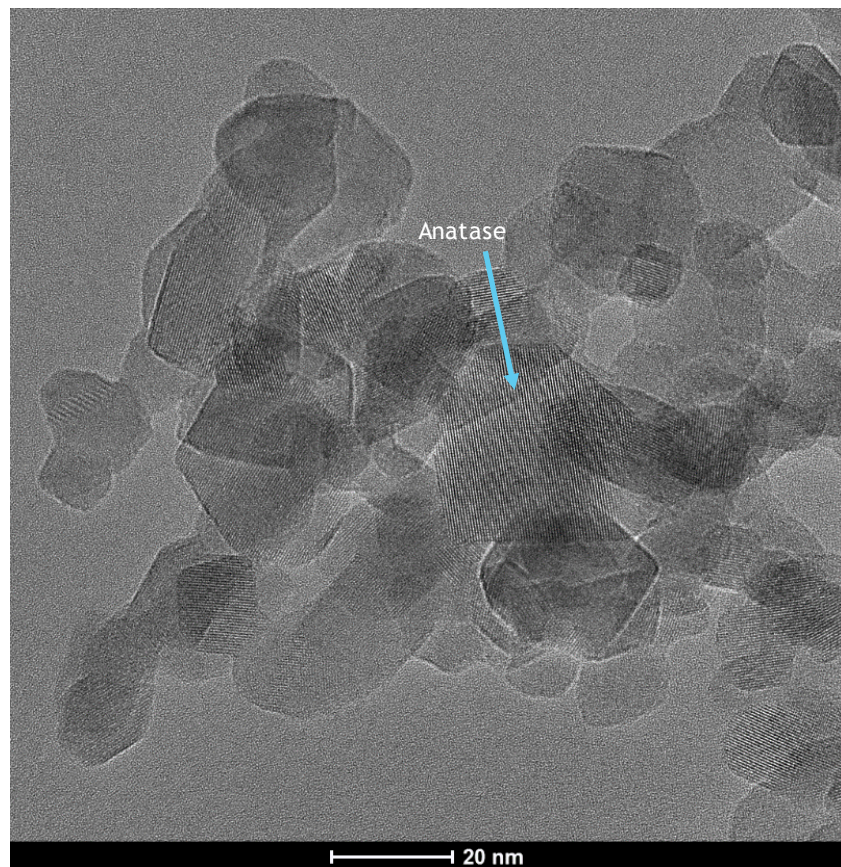
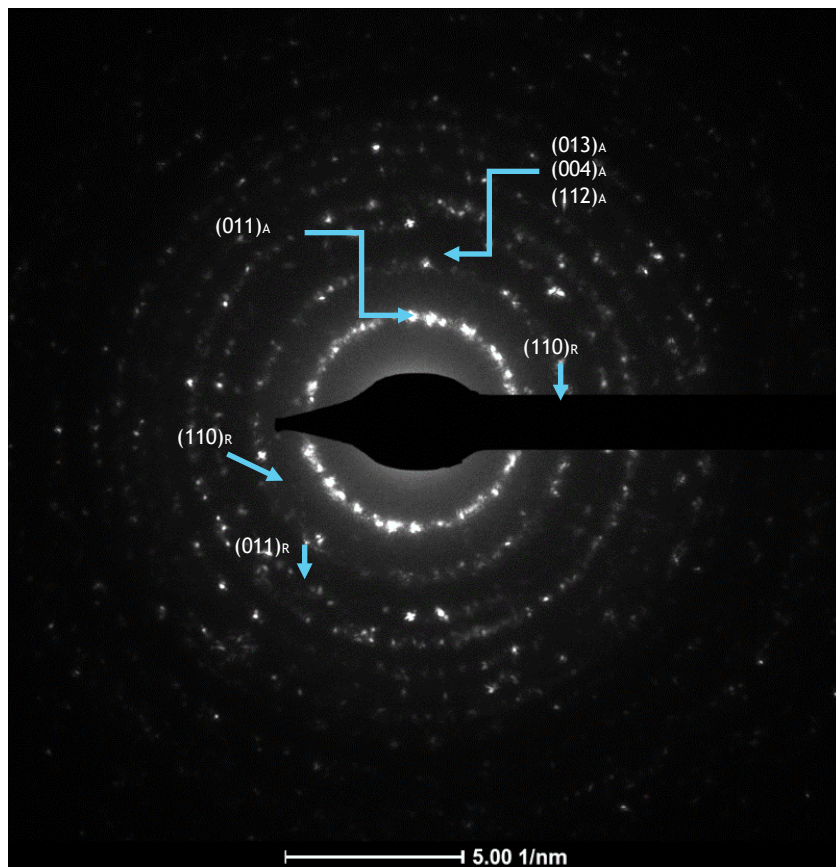
- ▶ At this magnification, W vacancies are visible (not necessarily the Se vacancies)
- ▶ The defect density (W vacancy) estimated in the order of  $10^{10} \text{cm}^{-1}$ , which is equivalent to finding 1 vacancy among ~100,000 W atoms. Each one of these pictures contain 20,000 W atoms.





## Ruthenium on Titanium dioxide (Ru/TiO<sub>2</sub>) Catalyst - Collaboration with Barnard College

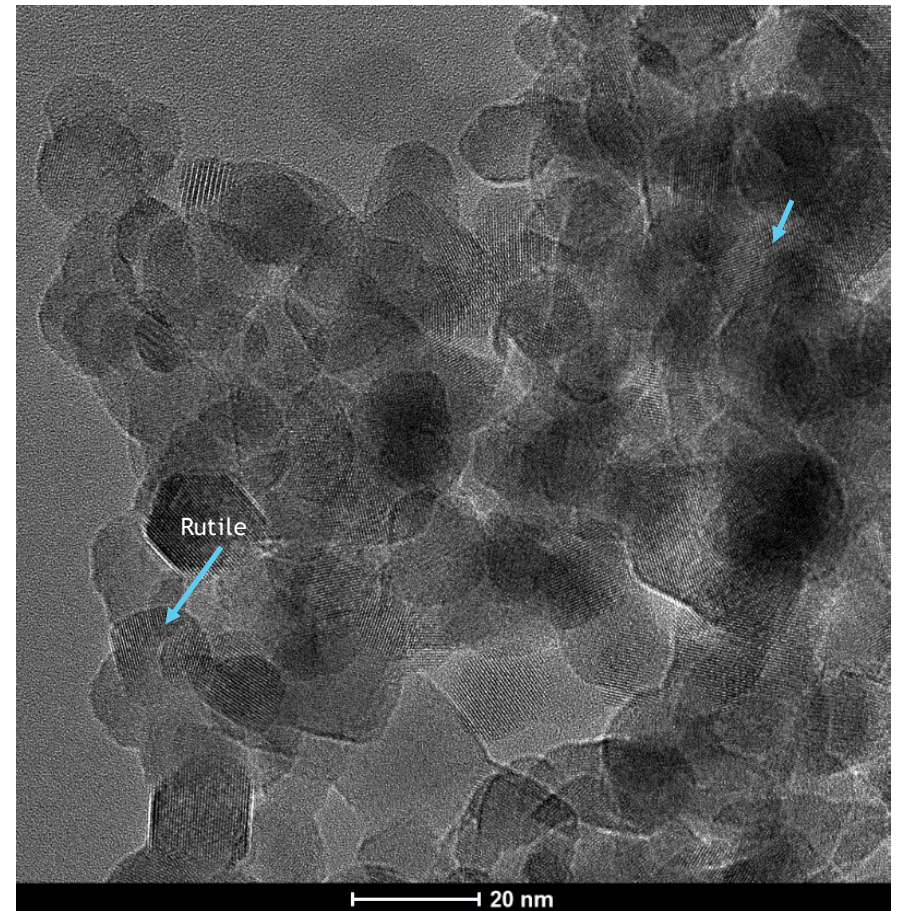
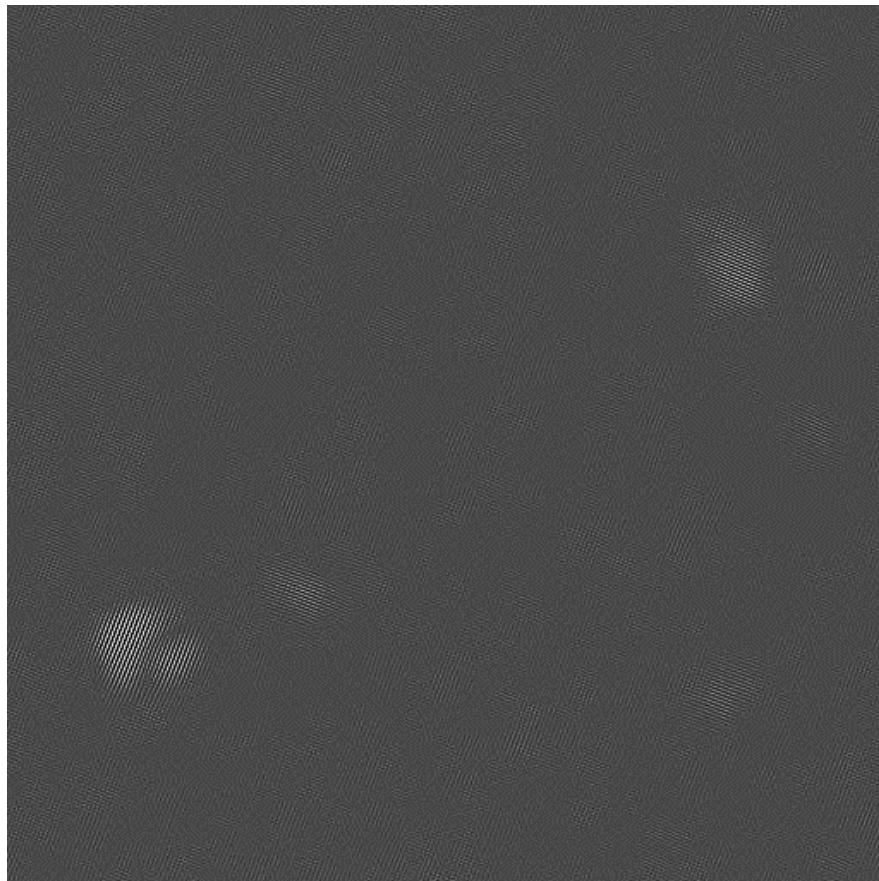
- ▶ The TEM images mainly show the anatase grains (with ~30 nm grain size)
- ▶ Some grains are oriented in a way the their atom columns are observable. This is being used to detect rutile grains.
- ▶ Faceting in some grains can be seen.





## HRTEM and Fast Fourier Transform (FFT) analysis

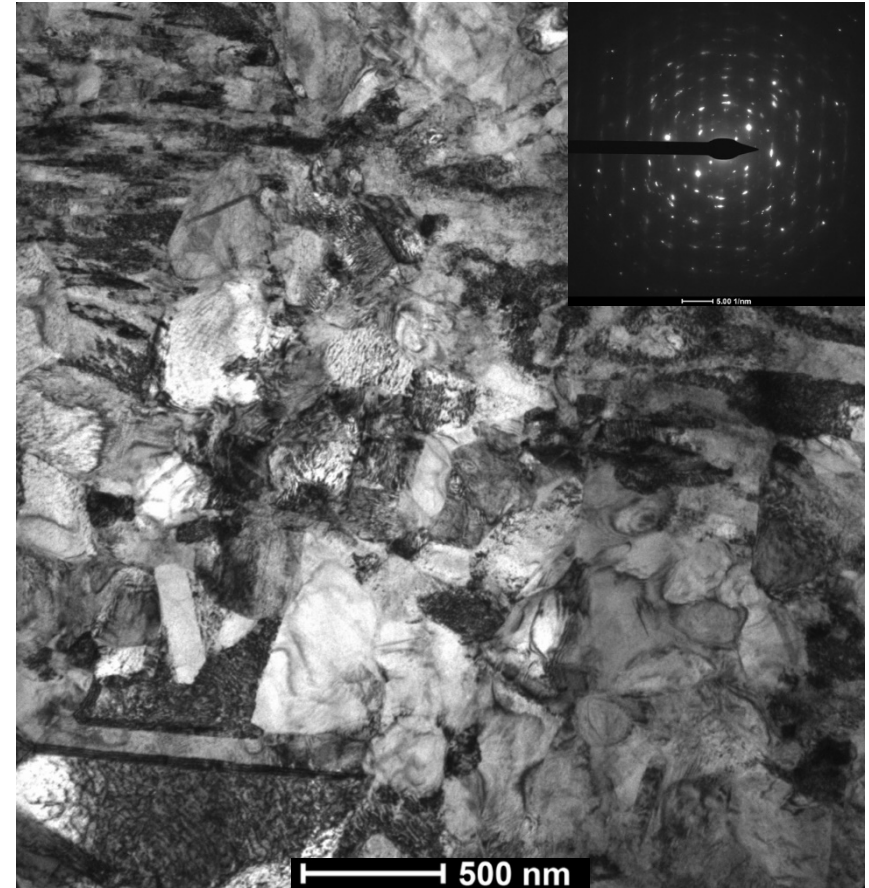
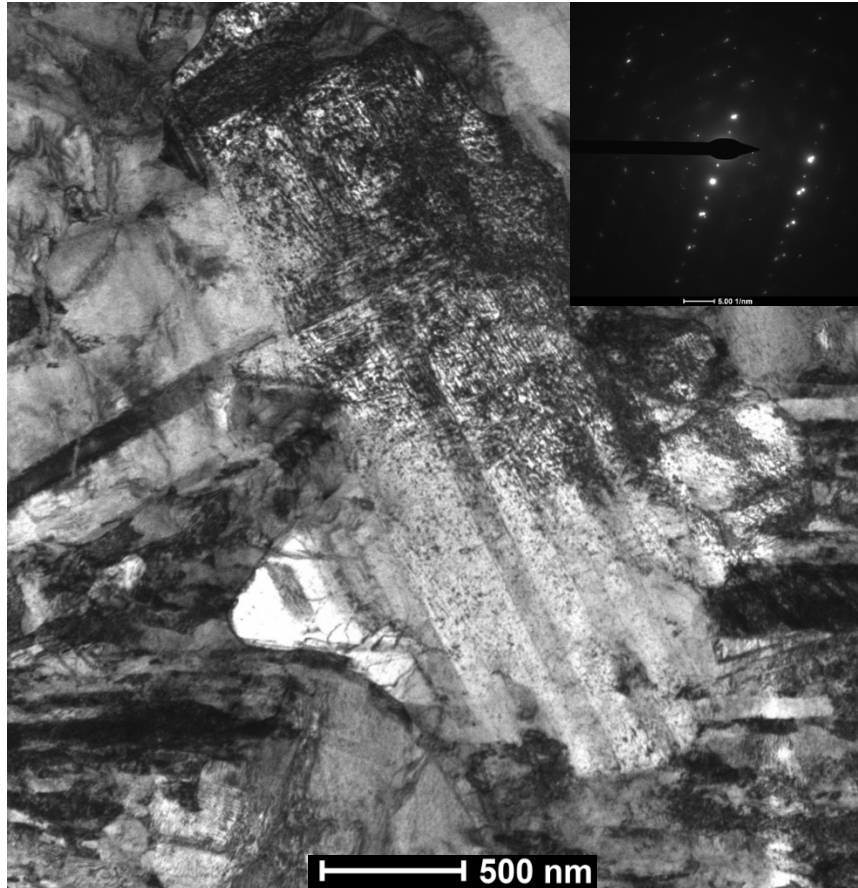
- ▶ After examining several HRTEM images, one rutile grain was found (which is fulfilling the Bragg angle).  $(110)_R$  plane is masked.
- ▶ This grain is smaller/have similar size compared to the anatase grains.





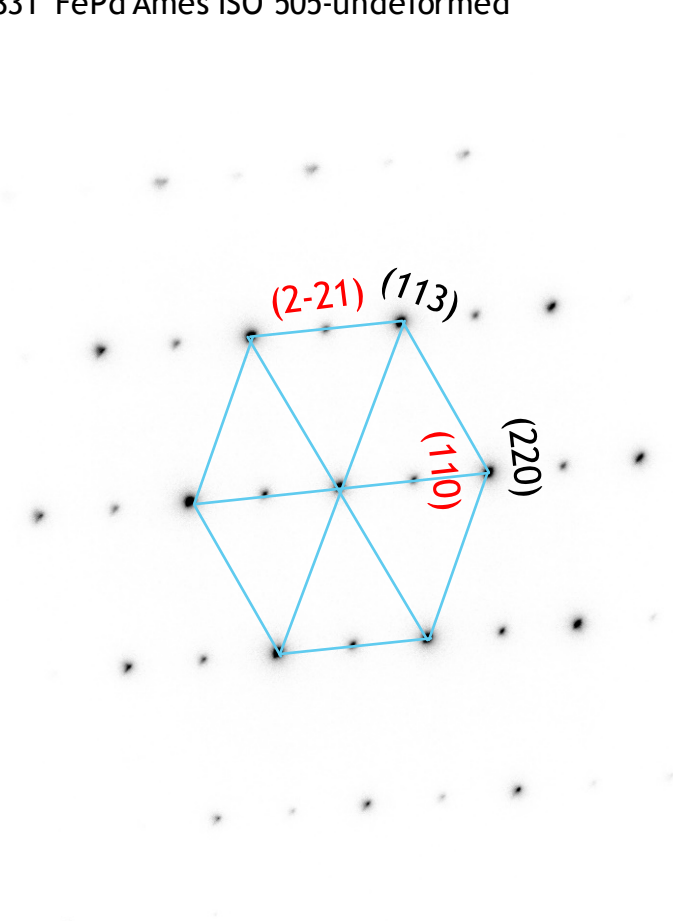
## FePd Highly Magnetic Material - Collaboration with Northeastern Univ.

20150831 Deformed 505°C (TD-ND) – (TD-RD is under preparation)

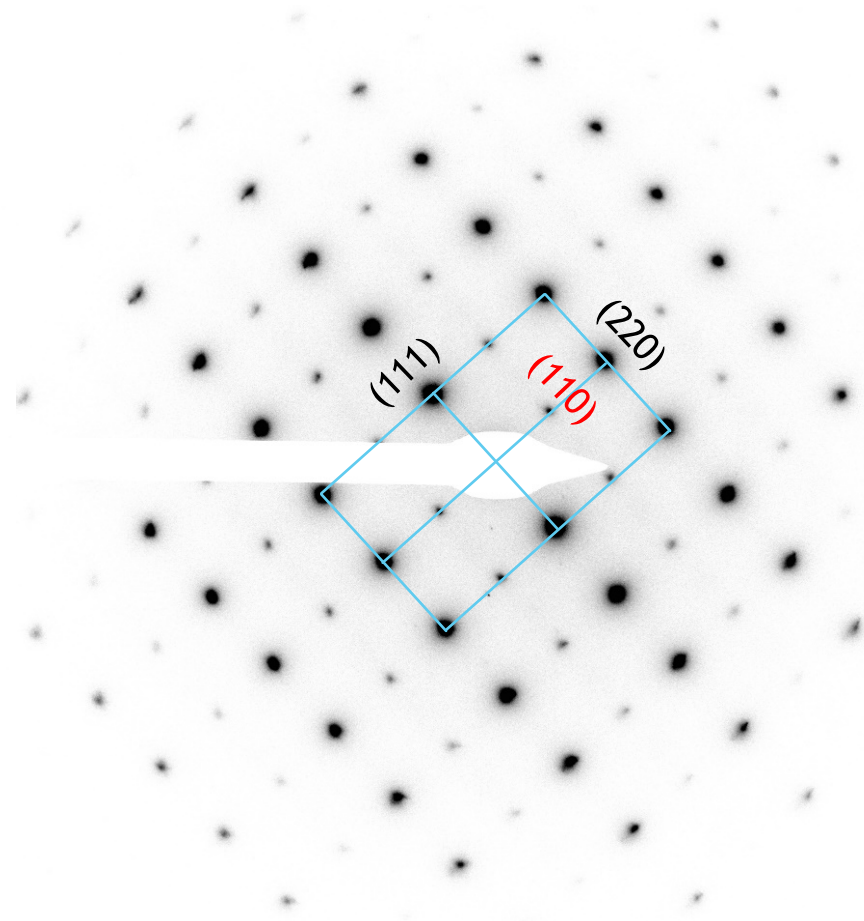


# Collaboration with Northeastern Univ.

20150831 FePd Ames ISO 505-undeformed



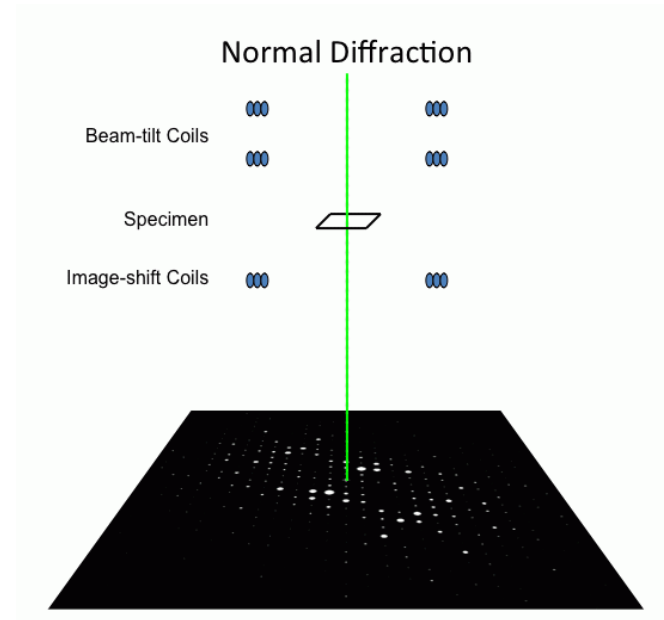
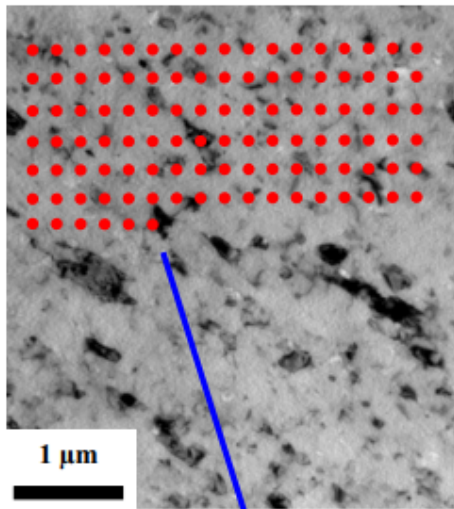
5.00 1/nm  
[114] zone axis



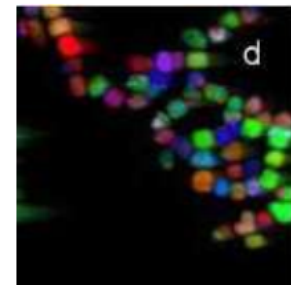
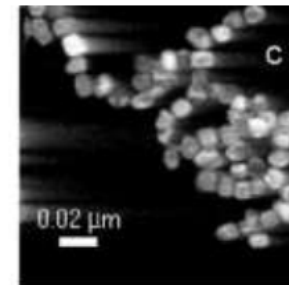
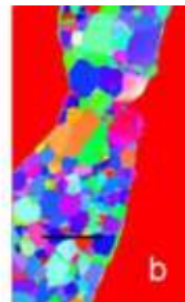
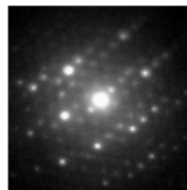
5.00 1/nm  
[110] zone axis

# ASTAR - Crystal Orientation Mapping

- A sample area is scanned by a nanometer electron beam
- Spot diffraction patterns are collected from scanned sample area
- Cross-correlation comparison of all acquired patterns with all simulated template
- Crystal orientation identification



Example :Severely deformed  
7075 Aluminium Alloy





# Question?

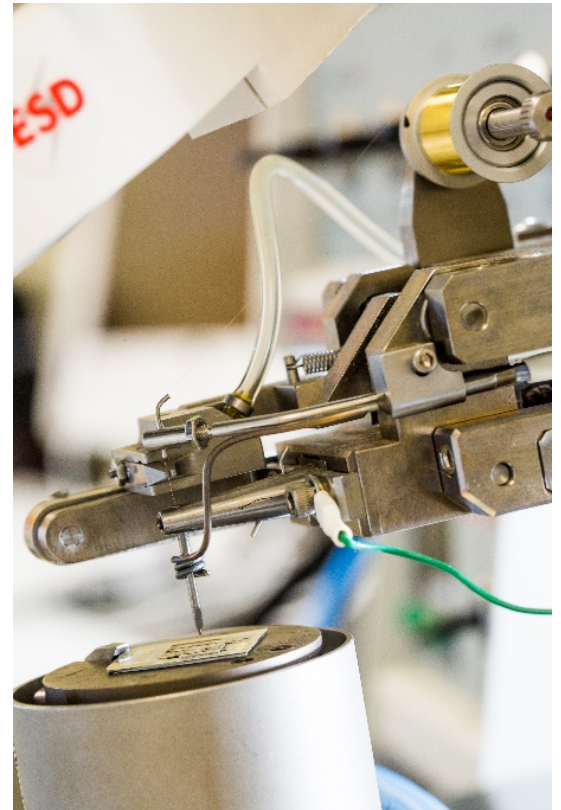
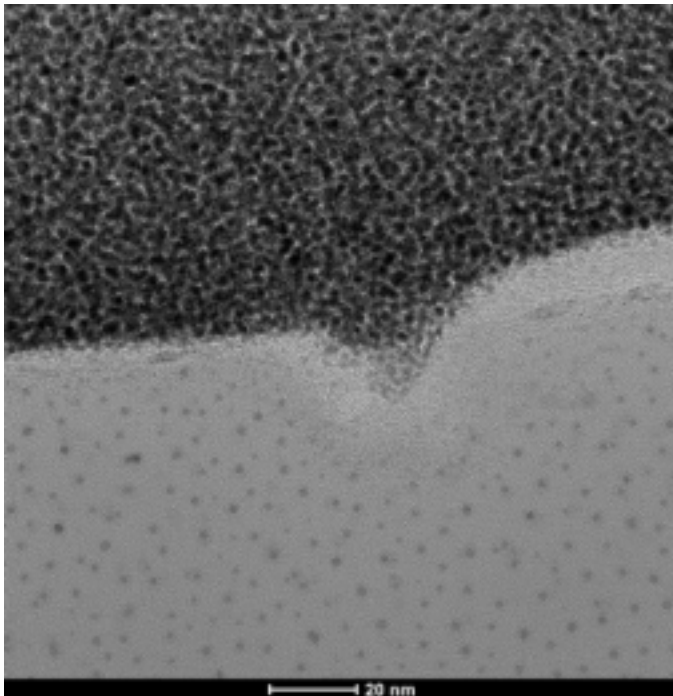
For more information go to:

<http://cni.columbia.edu/shared-labs/> or contact:

[na2661@columbia.edu](mailto:na2661@columbia.edu)

[az2476@columbia.edu](mailto:az2476@columbia.edu), or

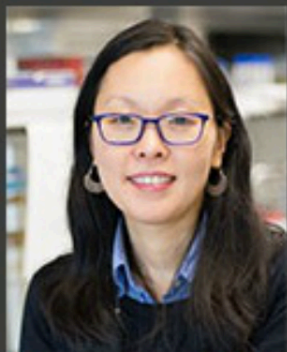
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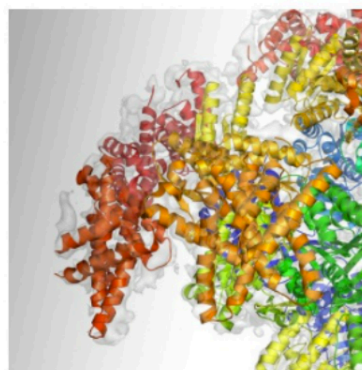
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The background features abstract, overlapping geometric shapes in various shades of blue, ranging from light sky blue to deep navy blue. The shapes are primarily triangles and polygons, creating a modern, layered effect. The text is positioned in the upper left quadrant of the white space.